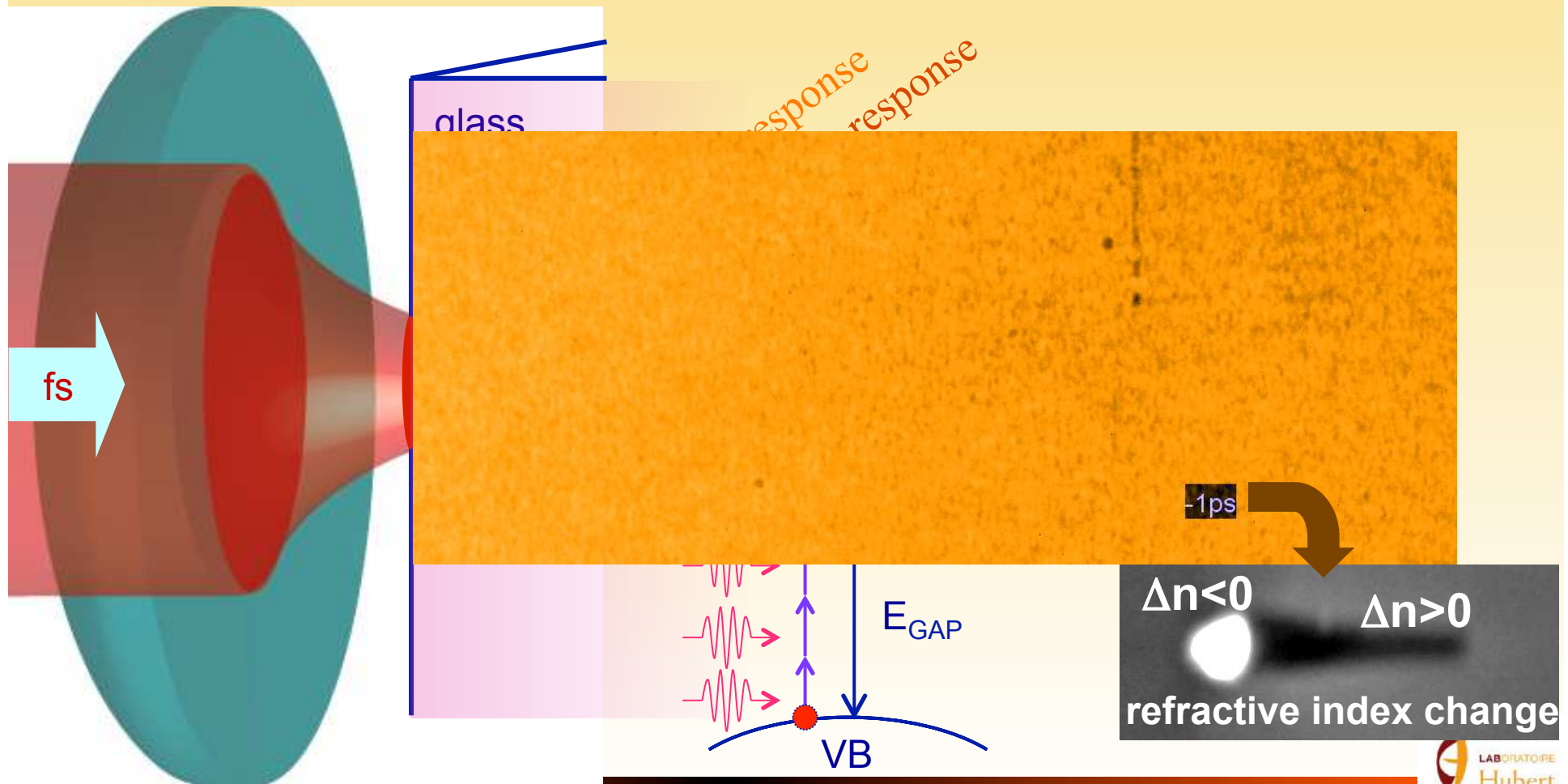


Ultrafast laser structuring beyond diffraction limit applications in 3D photonics

R. STOIAN



3D nonlinear excitation: ultrafast laser pulses



material modifications

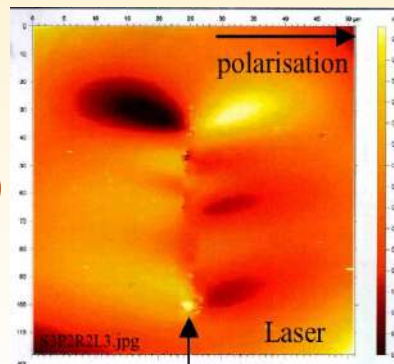
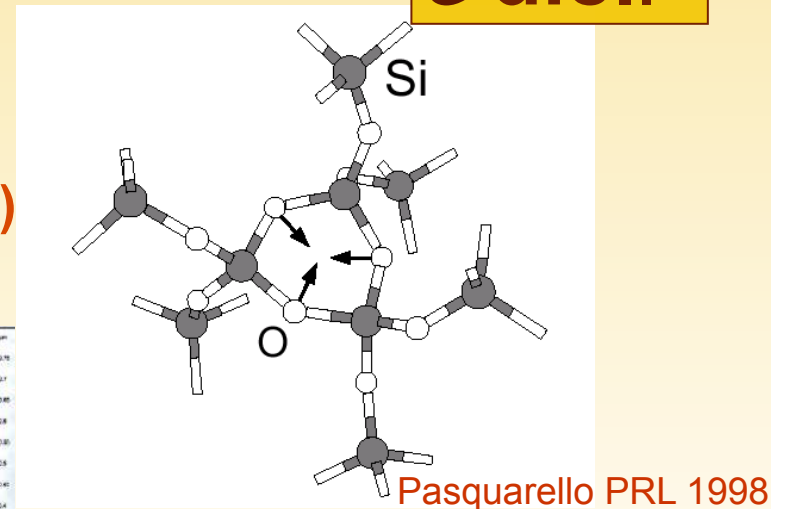
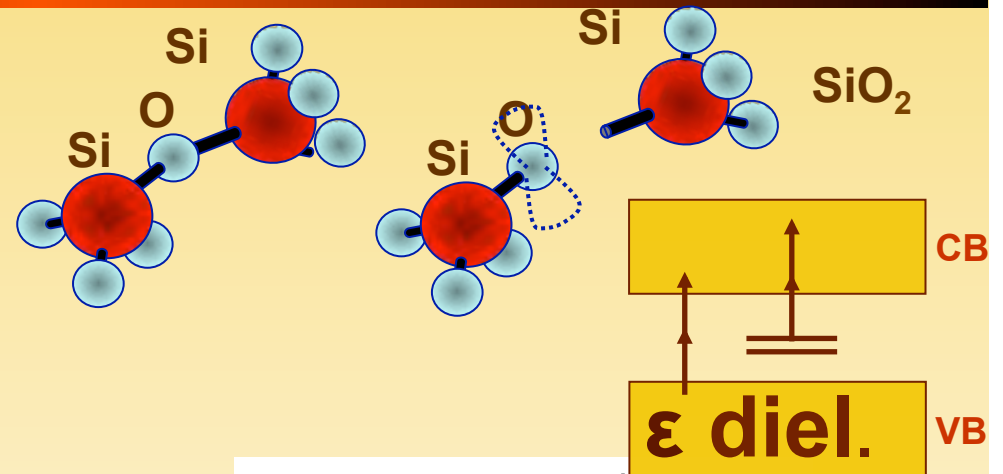
refractive index Δn

- interplay between

⇒ defects (energetic path)

⇒ densification (thermodynamic path)

⇒ stress (mechanical)

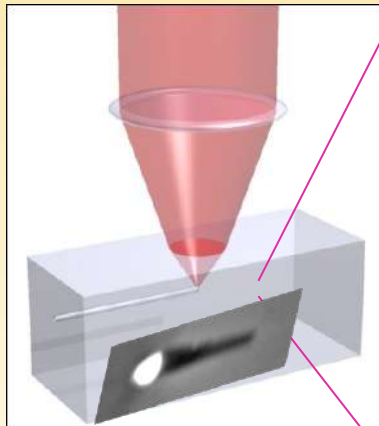


Poumellec OE 2003

3D material modifications: 3D optics

refractive index Δn

Building block of embedded 3D optical functions

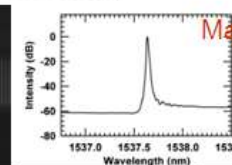
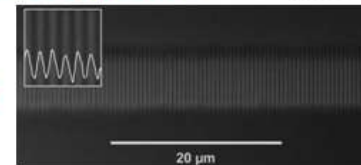


Fabrication

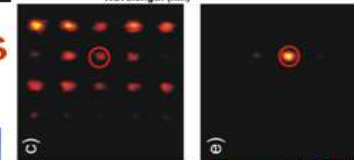
- Embedded optical elements
- Embedded lasers
- Photonic lattices, photonic crystals
- Quantum information
- Optofluidics
- Astrophotonics
- etc.....



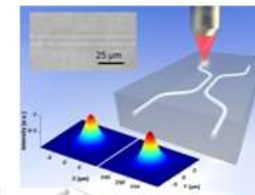
Watanabe OE 2002



Marshall OL 2008



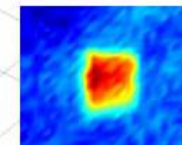
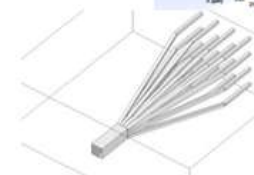
Szameit OE 2006



Sansoni PRL 2010



Cheng & Sugioka 2006



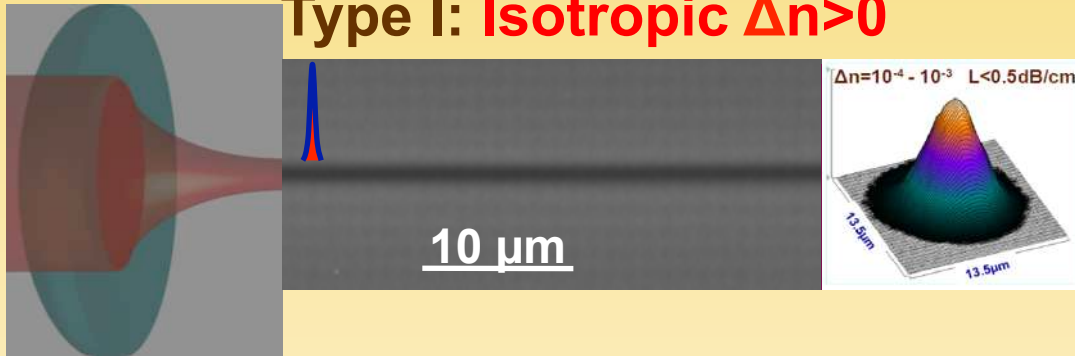
Thomson OE 2011

outline

- **Index change**
- **Index control**
- **Applications in 3D photonics**

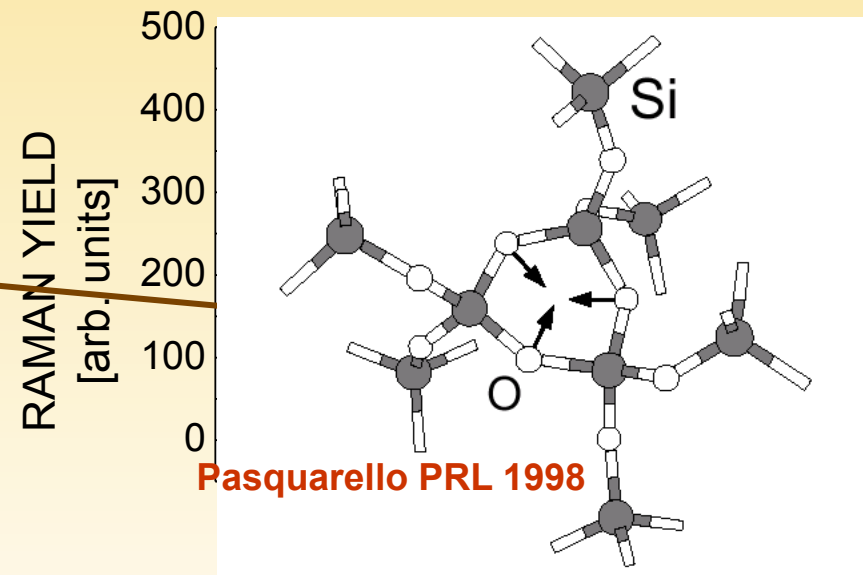
refractive index engineering: model a-SiO₂

Type I: **Isotropic $\Delta n > 0$**



What does this represent?

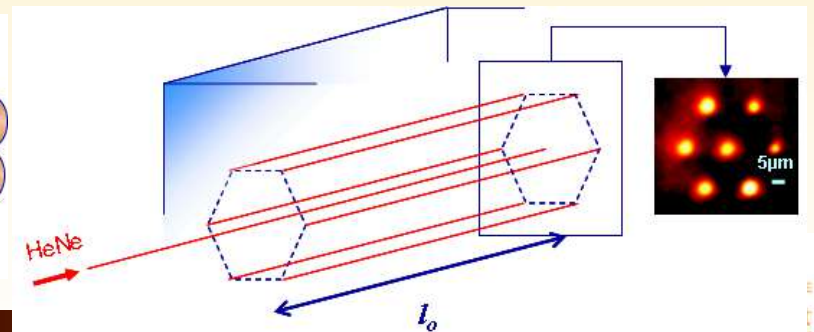
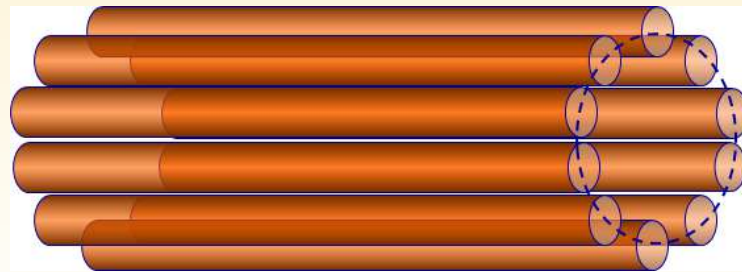
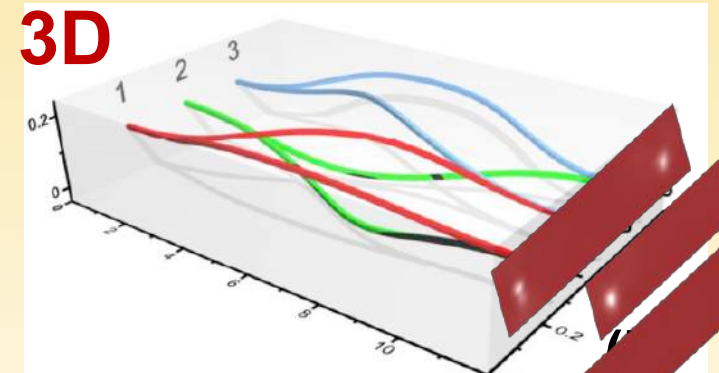
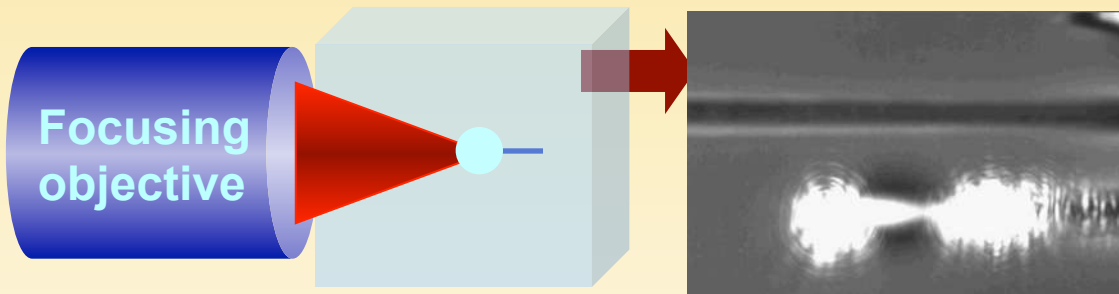
Accumulation
of bond breaking



Densification

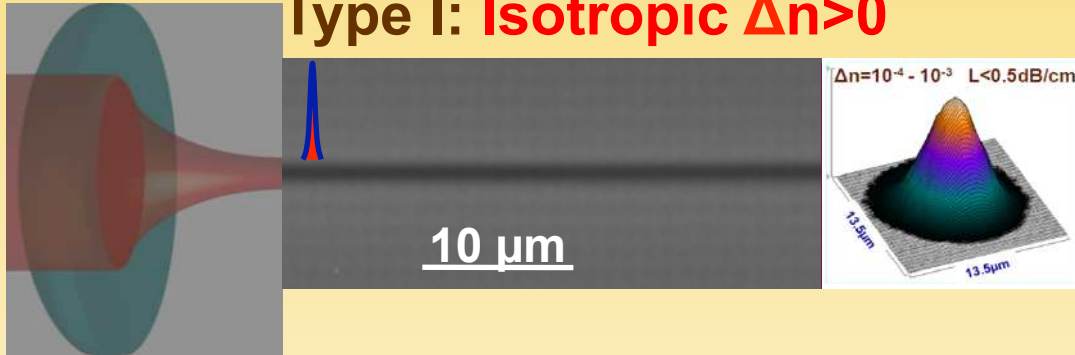
refractive index engineering: model a-SiO₂

Type I: Isotropic $\Delta n > 0$

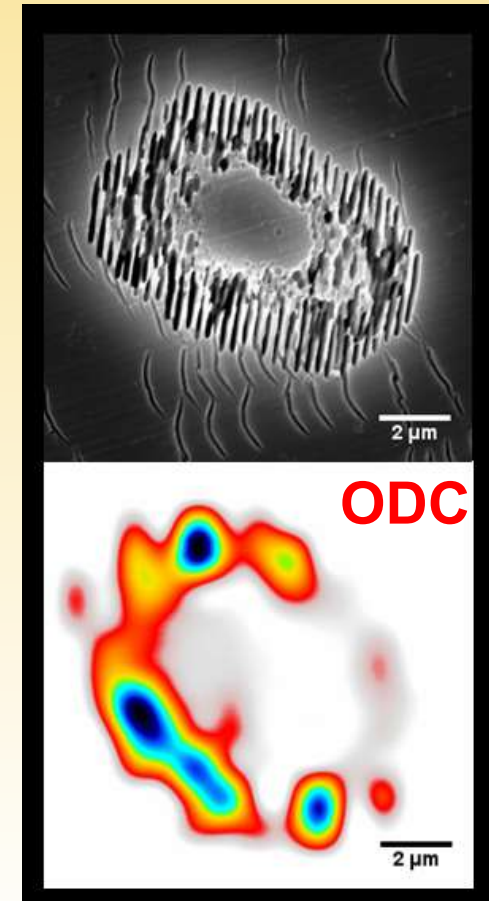
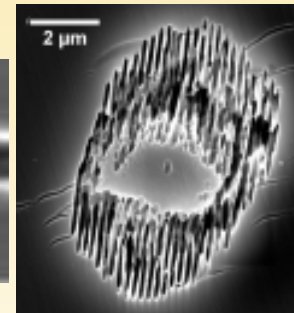
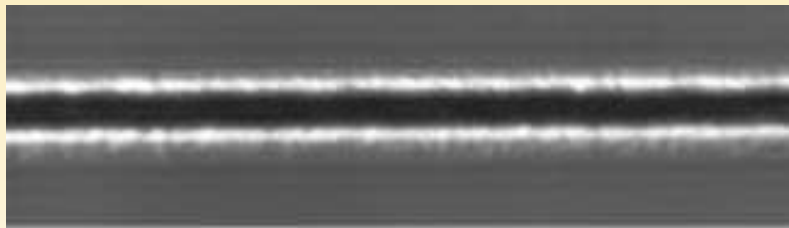


refractive index engineering: model a-SiO₂

Type I: Isotropic $\Delta n > 0$



Pulse manipulation
 E, N, τ_p

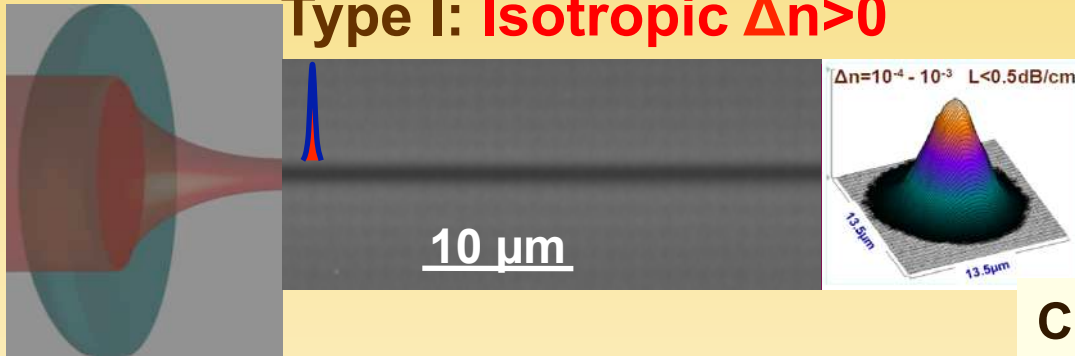


Type II Anisotropic Δn

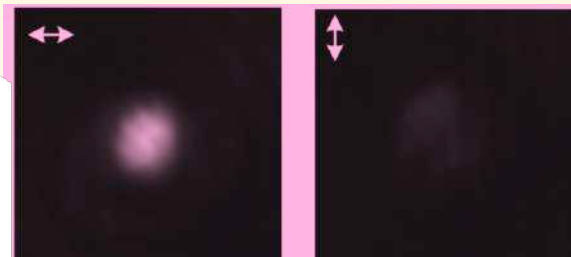
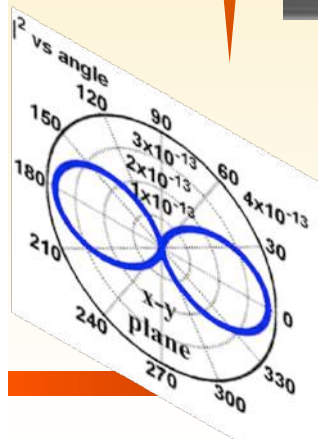
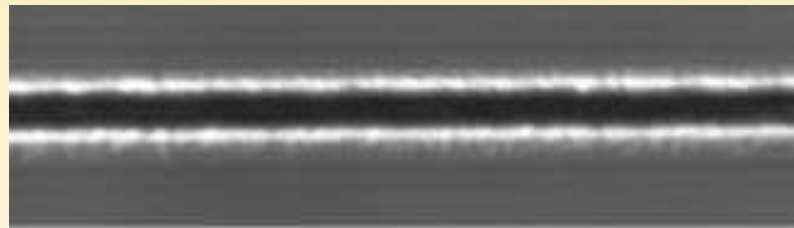
Nanogratings:
quasi-universal

refractive index engineering: model a-SiO₂

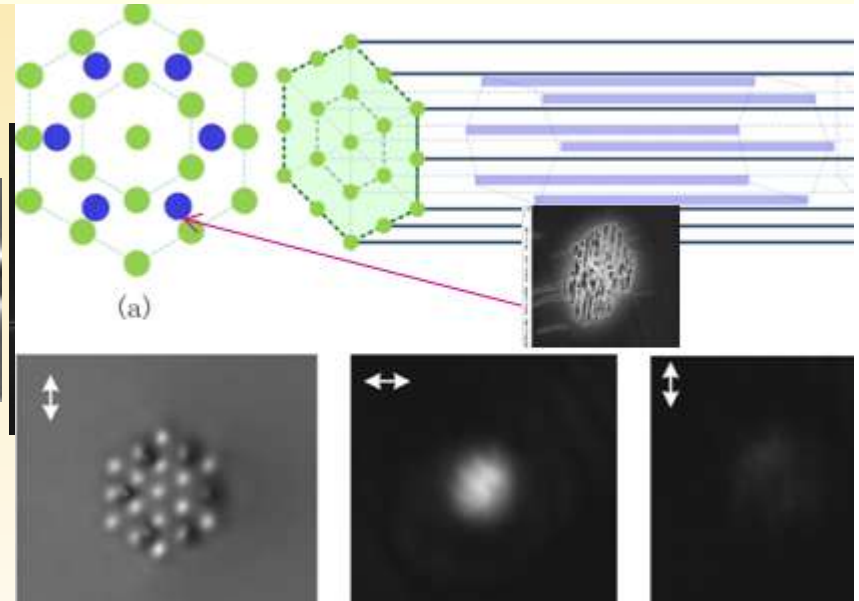
Type I: Isotropic $\Delta n > 0$



Pulse manipulation
 E, N, τ_p

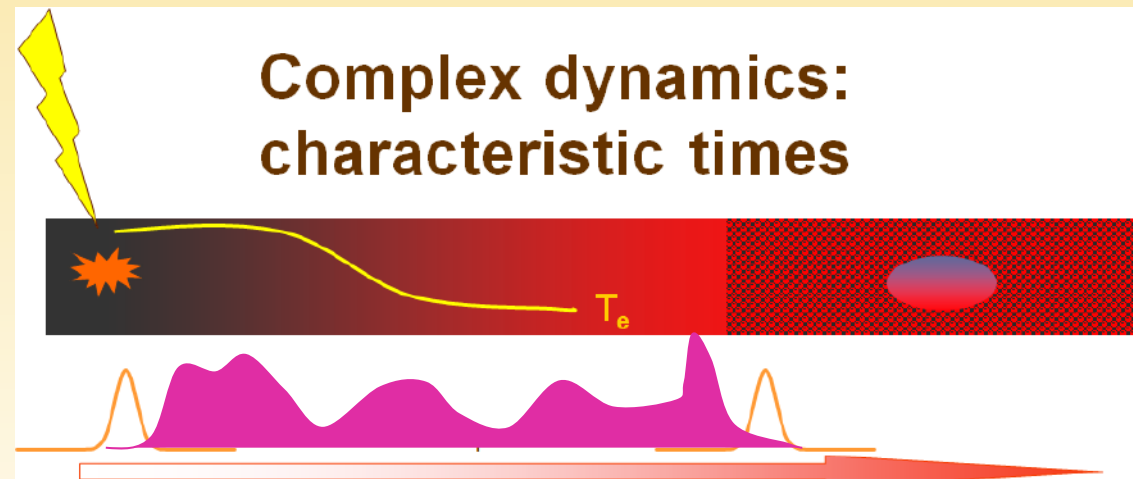
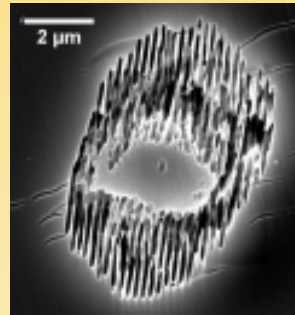
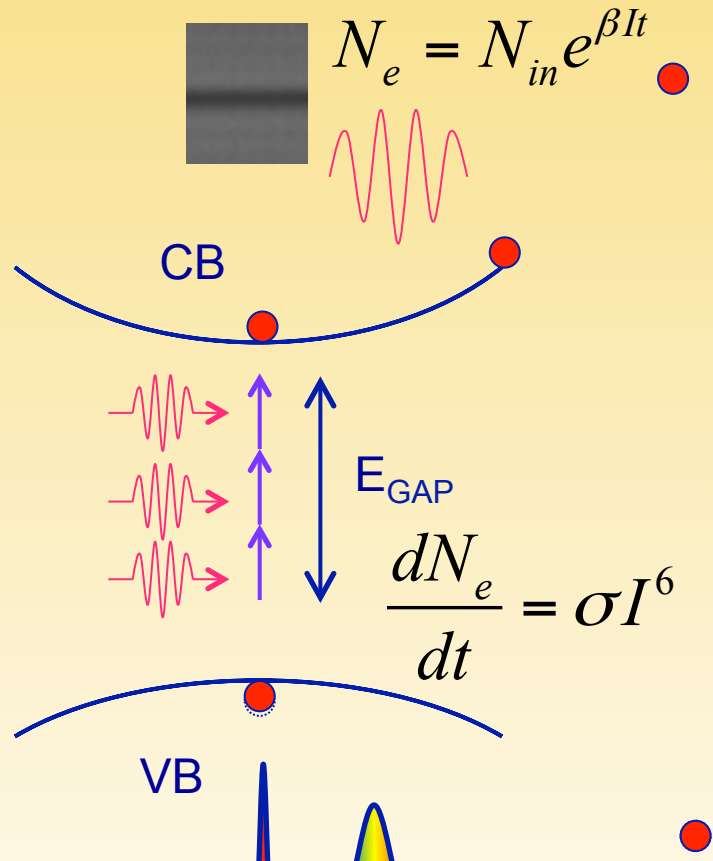


Combination: low loss polarization

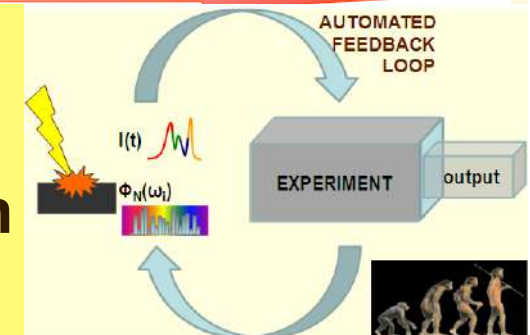


Polarization sensitivity

3D nonlinear excitation: ultrafast laser pulses



Controlling light-matter interaction on smallest scales: spatio-temporal pulse design (index engineering)



optimizing the laser action

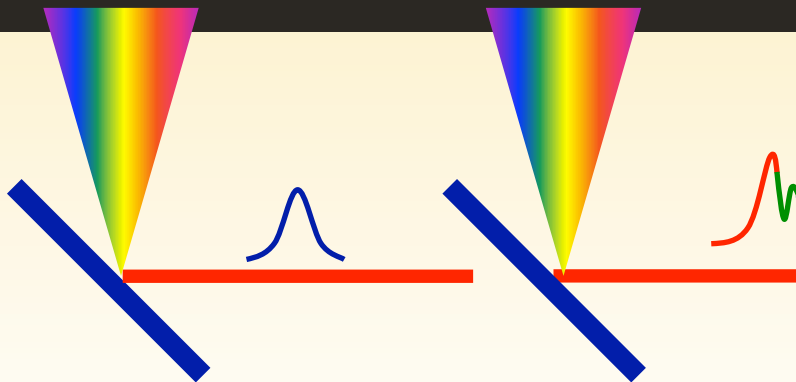
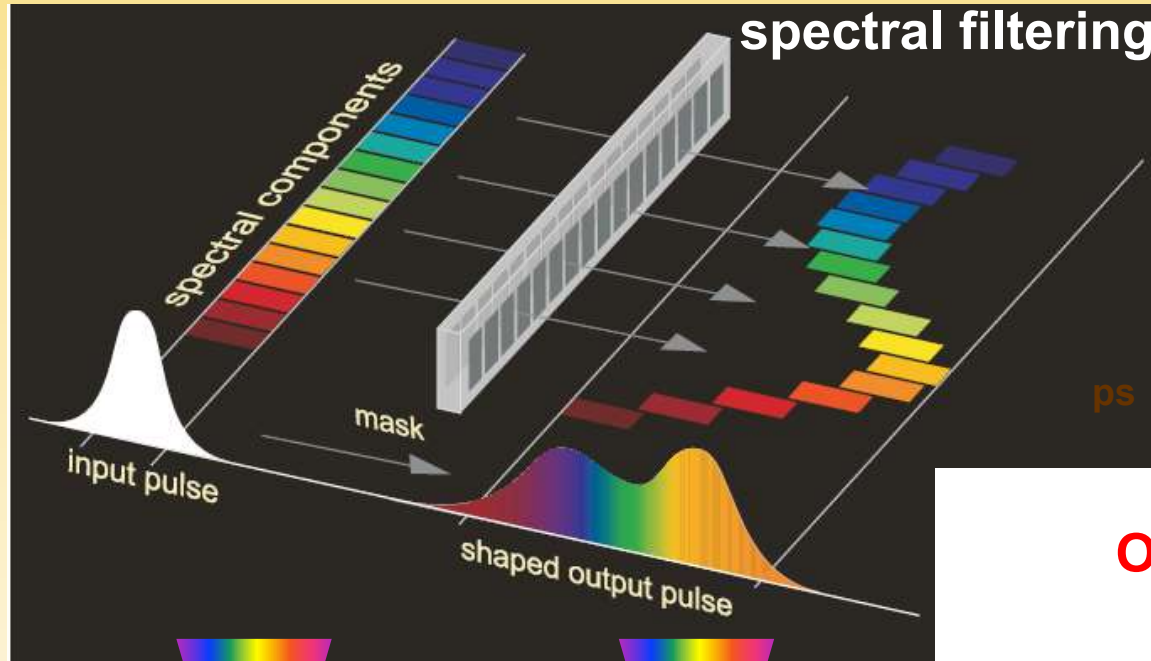
Idea

- Design radiation according to the material response

Technique

- Pulse temporal shaping

designing pulses in time



OPTIMAL CONTROL



-synergetic design
evolution trajectories
IMPROVE PROCESS

applications: change standard material reaction

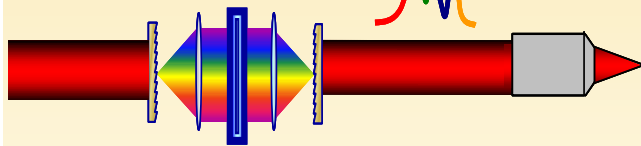
SiO₂ $\Delta n > 0$

$\alpha_{\text{BK7}} > \alpha_{\text{SiO}_2}$
BK7 $\Delta n < 0$

Can we change this?

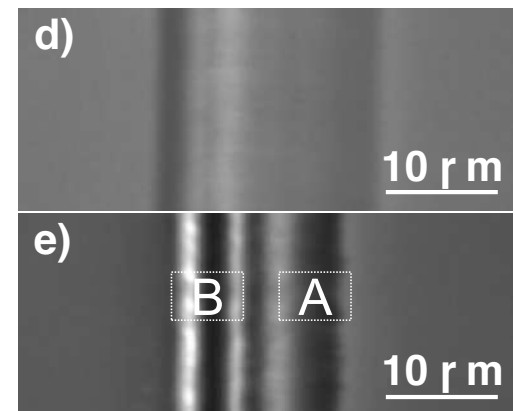
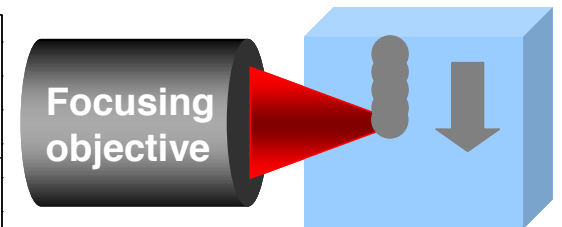
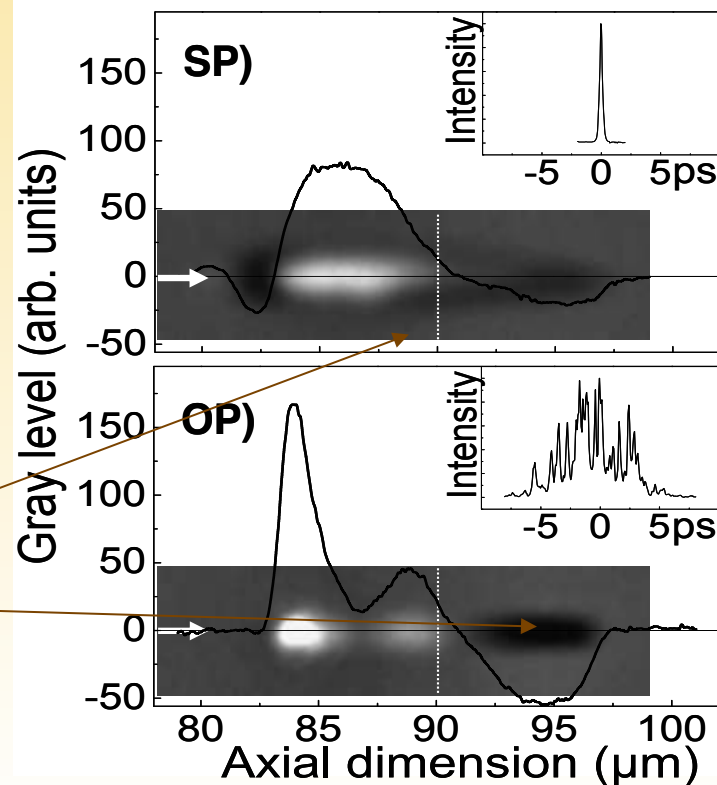
Index flip in BK7/difficult to process

Pulse shaping



$\Delta n < 0$

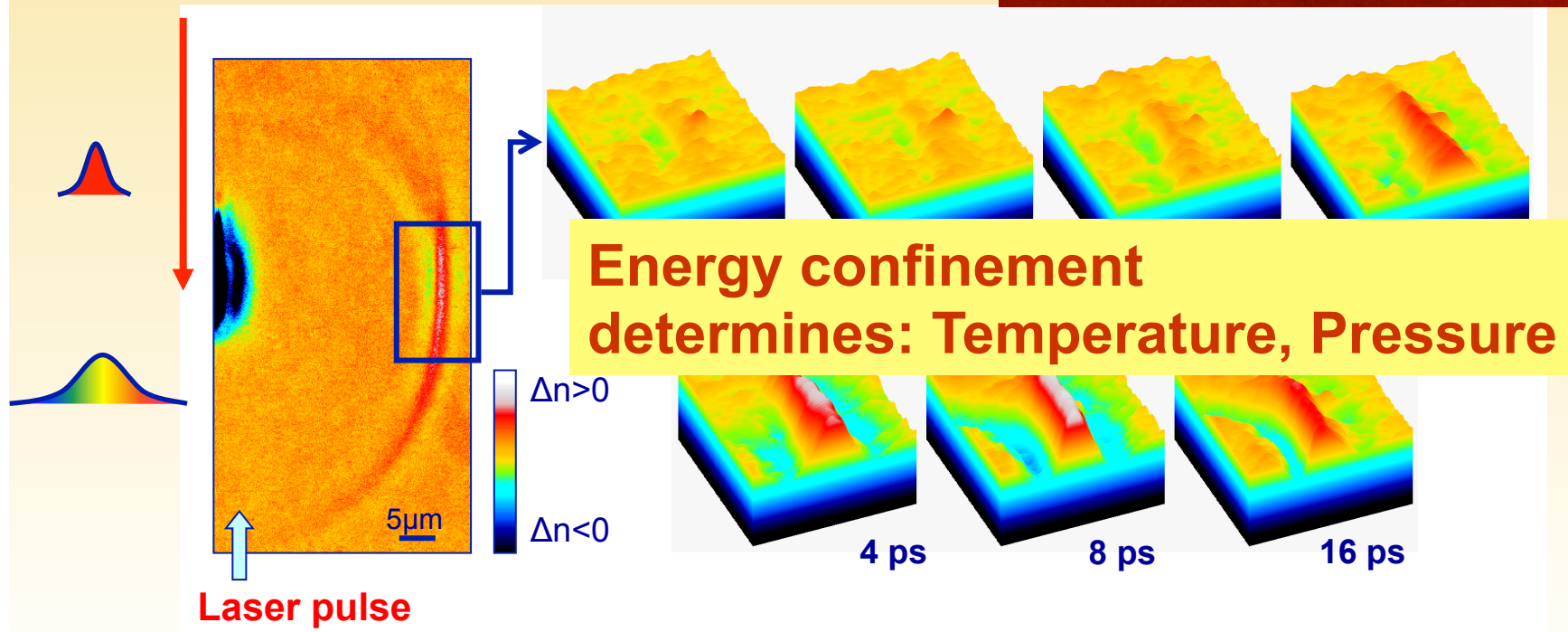
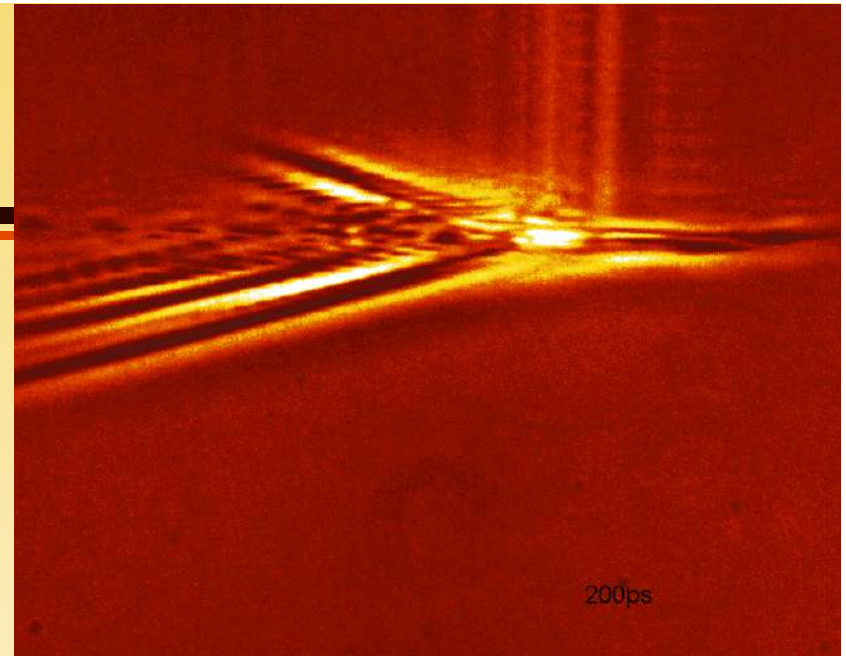
$\Delta n > 0$



energy confinement role of pulse duration

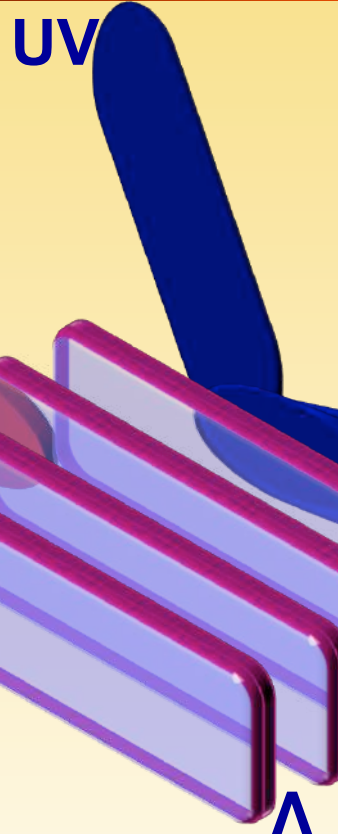
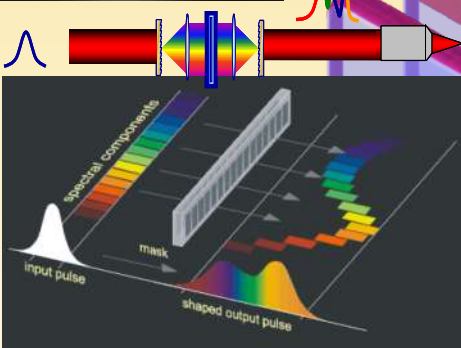
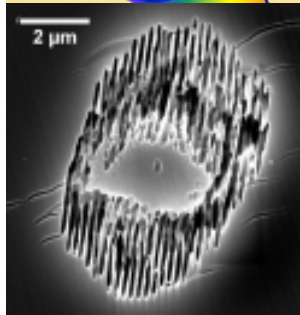
Pressure wave

- ps pulse – Stronger amplitude of the PW



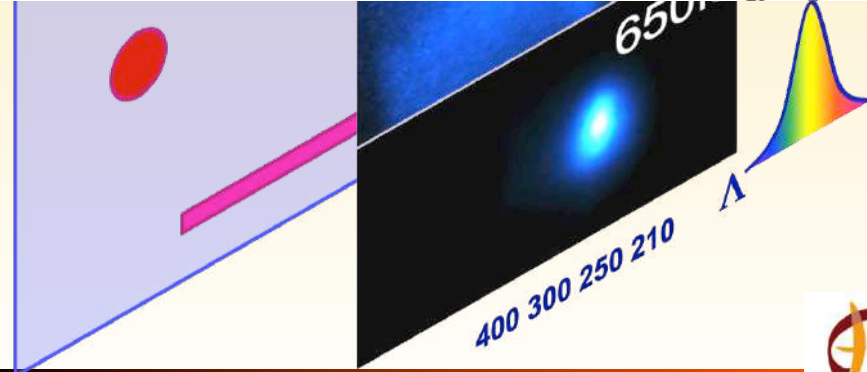
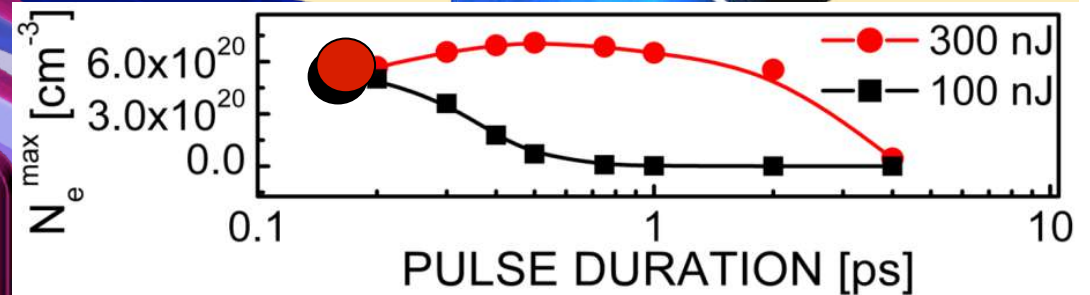
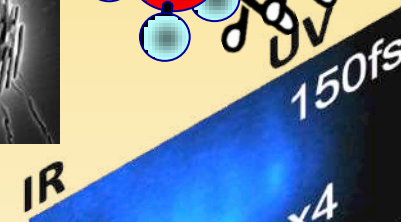
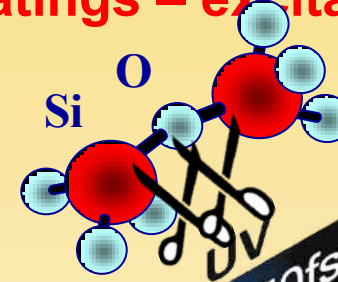
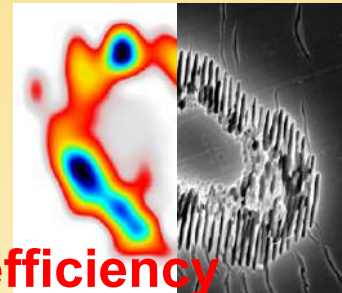
nano-control via diffraction feedback: a-SiO₂

Impact of excitation

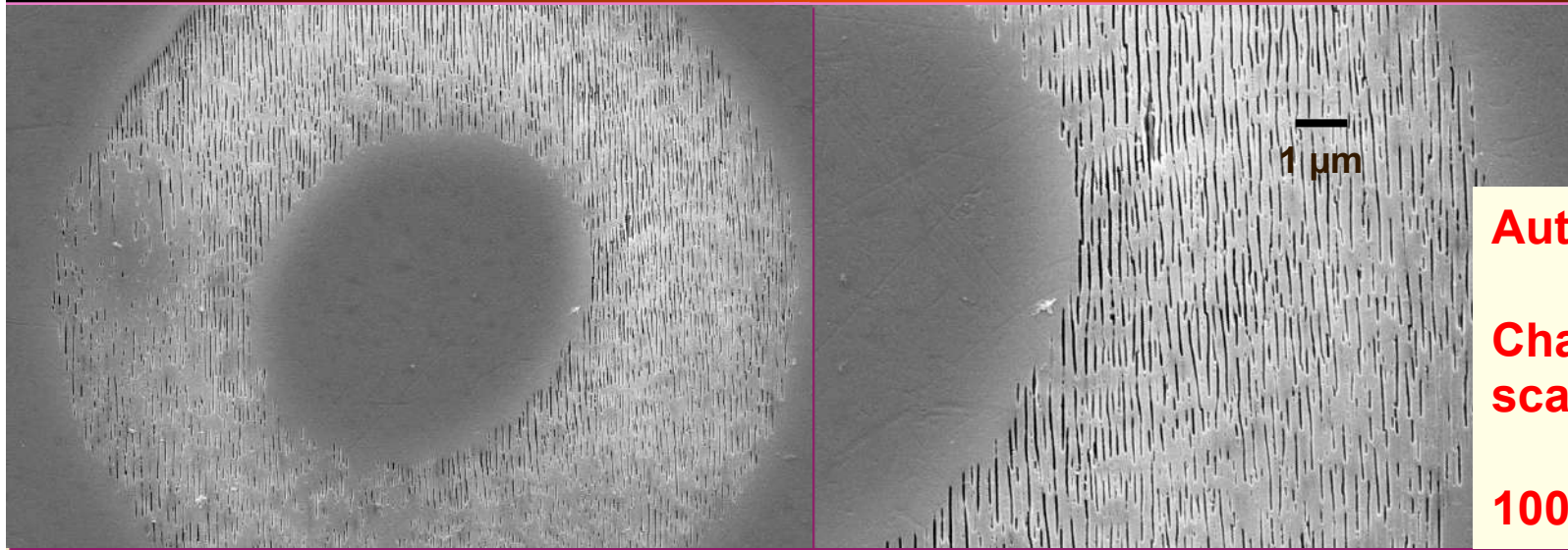


Relation: Nanogratings – excitation level

ODC
O-deficiency



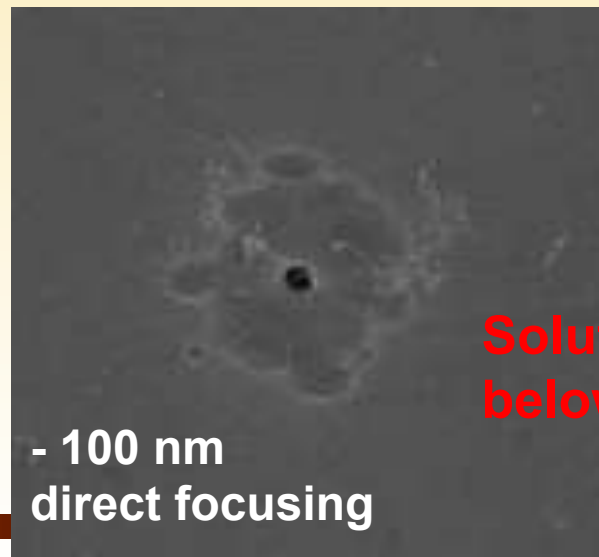
laser nanostructuring: beating the diffraction limit



Auto-organization

**Characteristic
scale**

100-200nm

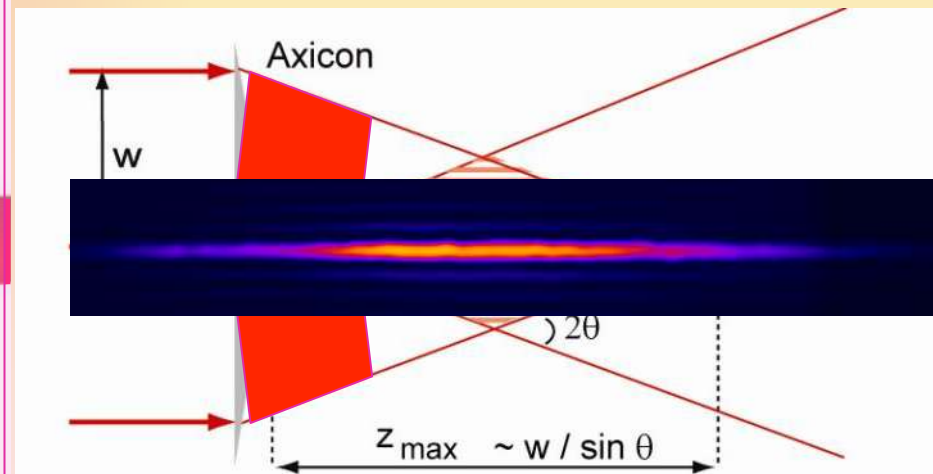
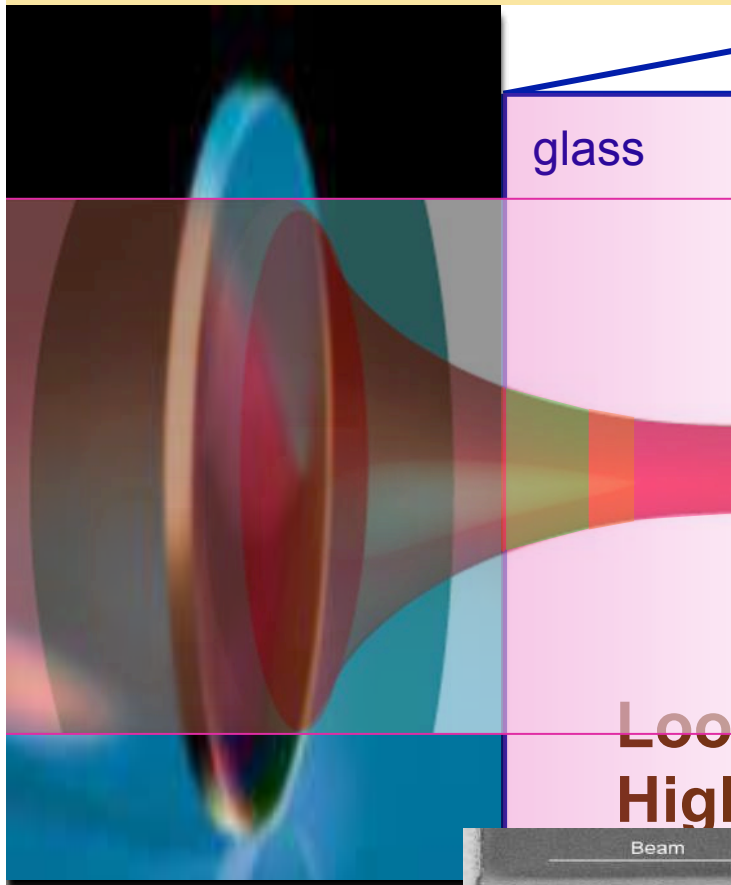


**Solutions for energy confinement
below the diffraction limit**

3D? giving-up dimensions

Bessel beams – a class of non-diffracting beams (2D)

$$E(r,z) = J_0(kr \sin \theta) \exp(ikz \cos \theta)$$

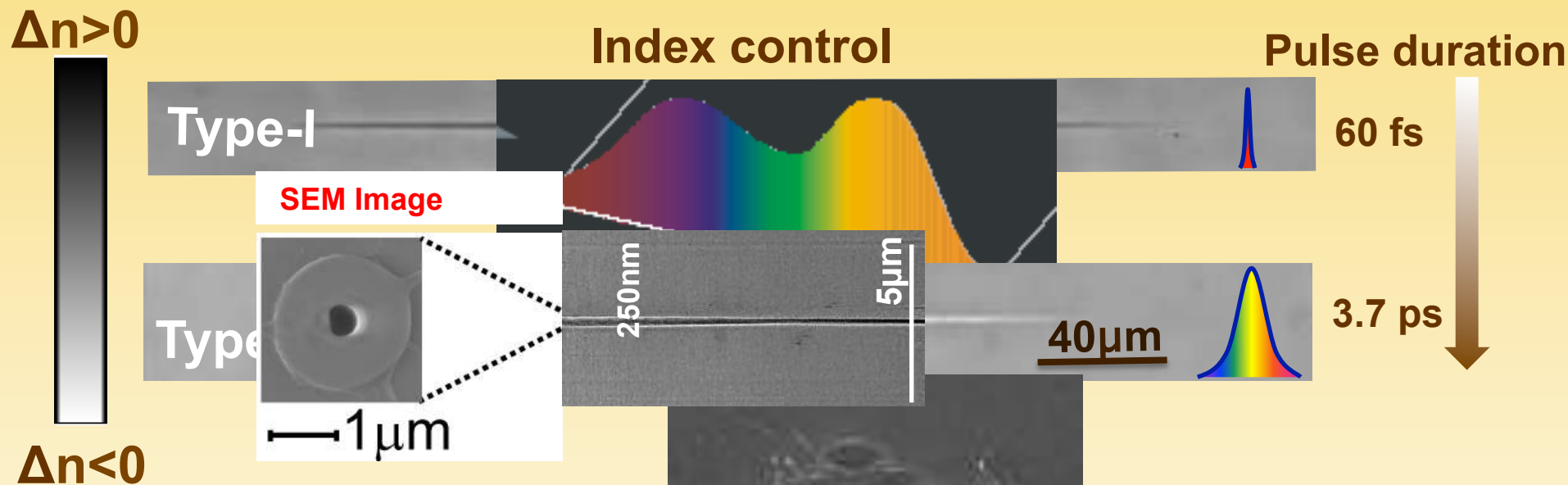


Loose focusing to maximize performance
High aspect ratios: 1000-10000

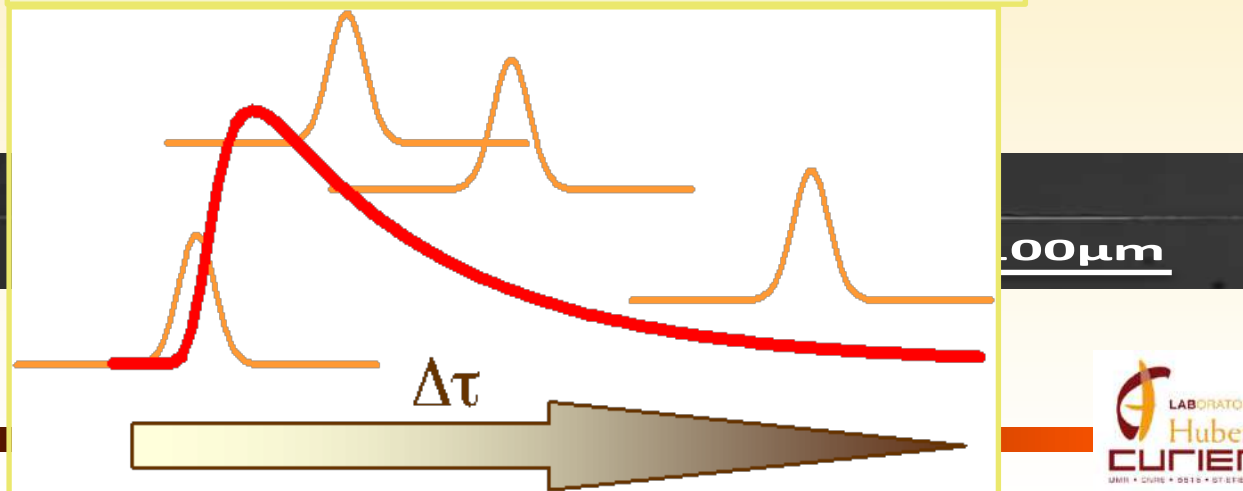


FEMTO-ST
Bhuyan APL 2010

non-diffractive: space and time design



Q: how to identify processes?



1 mm

Pulse duration is key

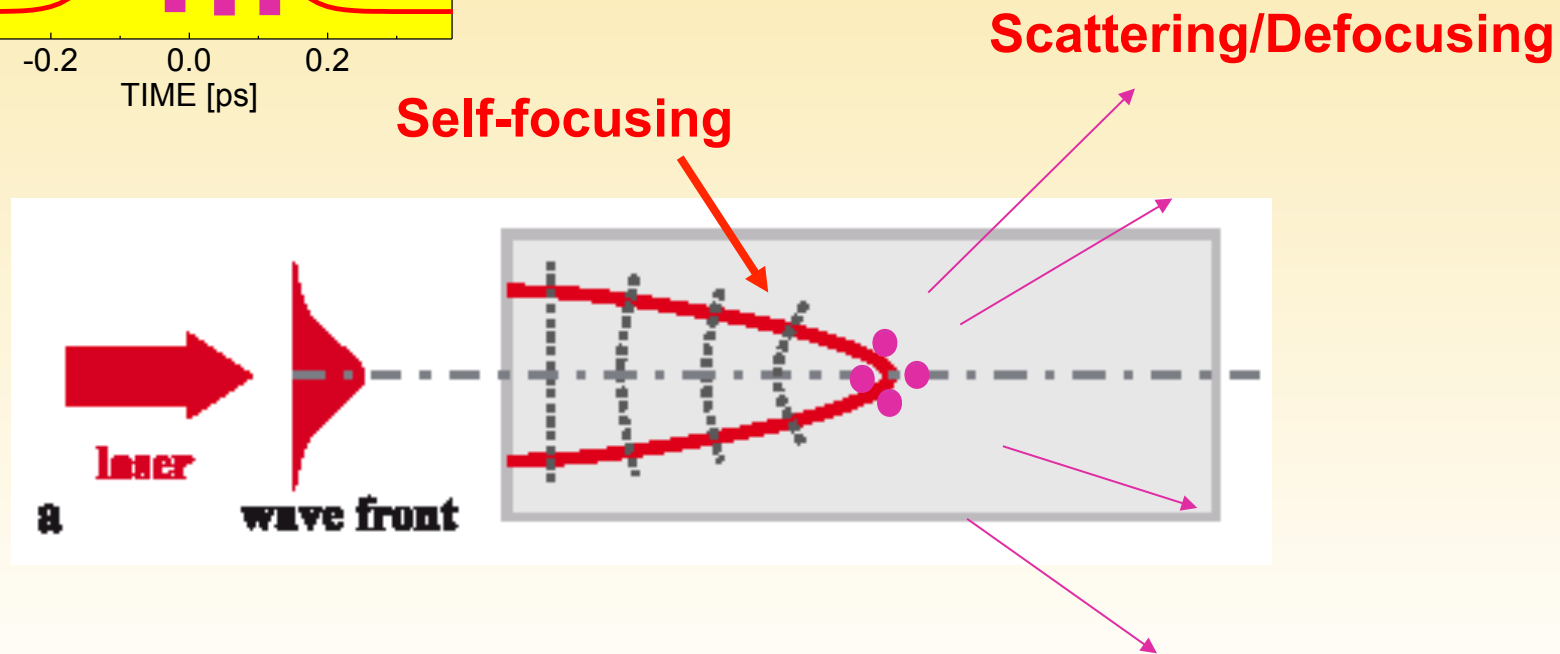
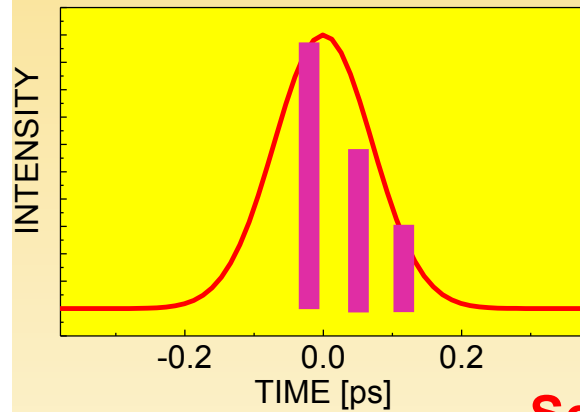
refractive index changes

Q: How is the energy deposited?

Q: How does the material react?

role of pulse duration: energy confinement

Nonlinear optical Schrödinger equation for propagation

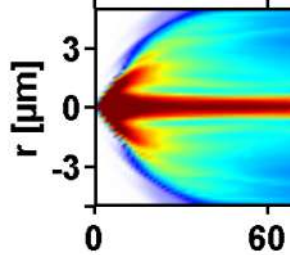


role of pulse duration: energy confinement

Nonlinear op

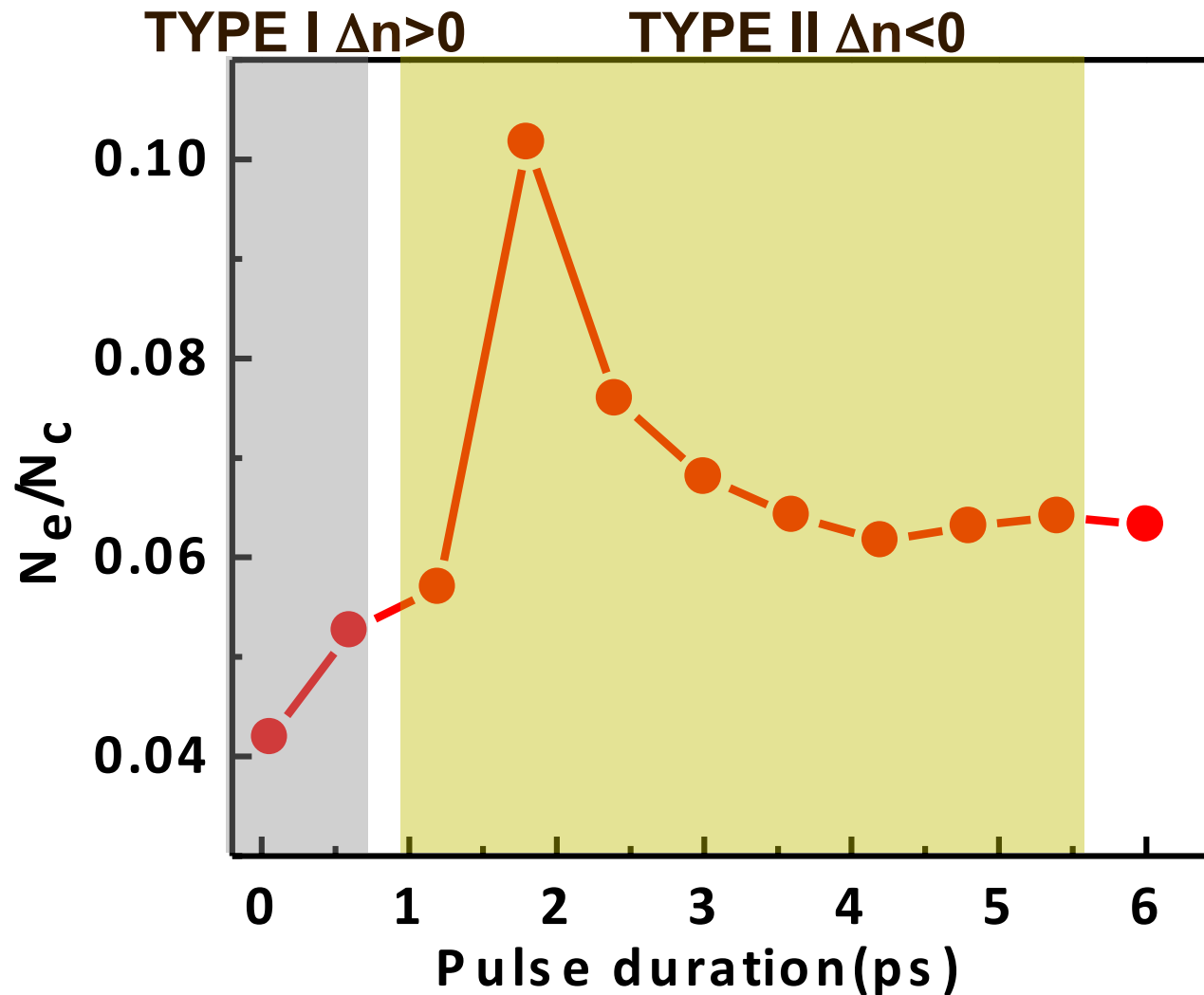
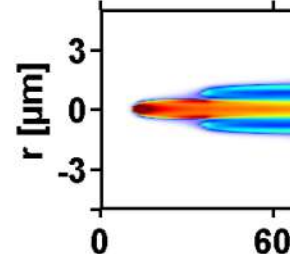
60 fs, 6 μ J

INTEGRATED



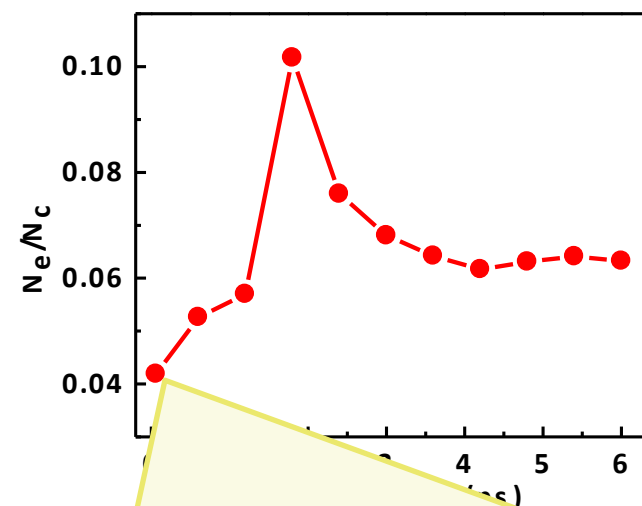
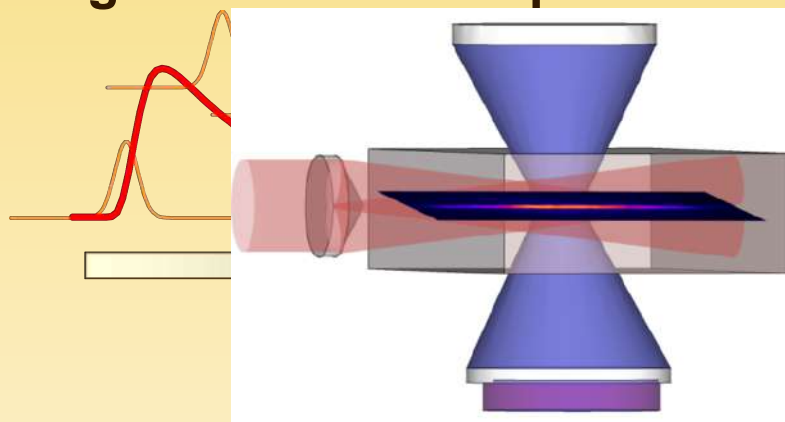
1.8 ps, 6 μ J

INTEGRATED



ultrafast dynamics: time-resolved imaging (fs)

Probing the material response:



Time-resolved microscopy

60 fs; Type-I smooth positive refractive index structures

1.25 μJ
(around the threshold)



ultrafast dynamics: time-resolved imaging (fs)

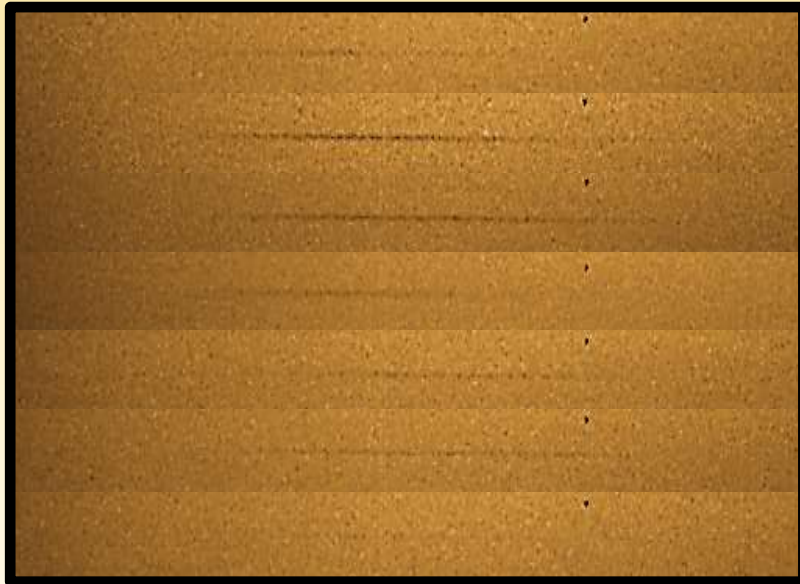
Around the modification threshold

1.25 μ J
60fs

-0.9ps

Optical transmission

Optical transmission images



Delay

-0.4ps

0ps

0.3ps

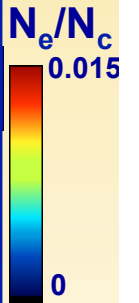
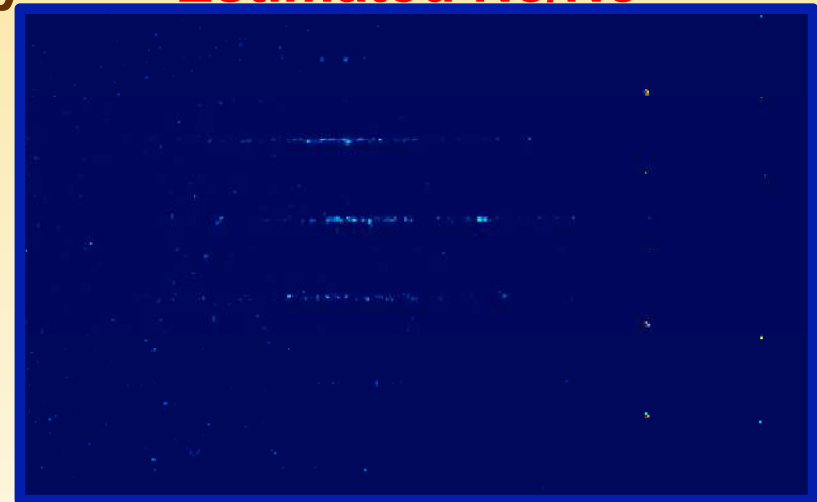
0.6ps

0.9ps

1.2ps

5ps

Estimated N_e/N_c



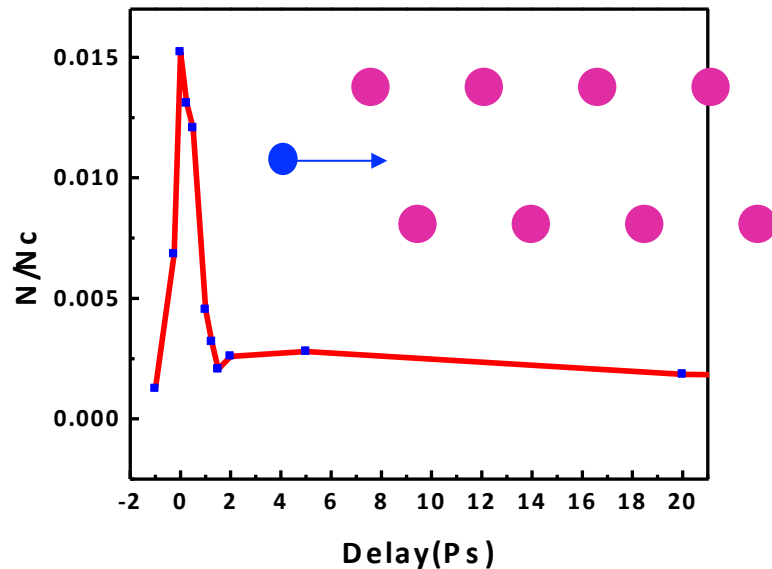
ultrafast dynamics: time-resolved imaging (fs)

Around the modification threshold

1.25 μ J
60fs

-0.9ps

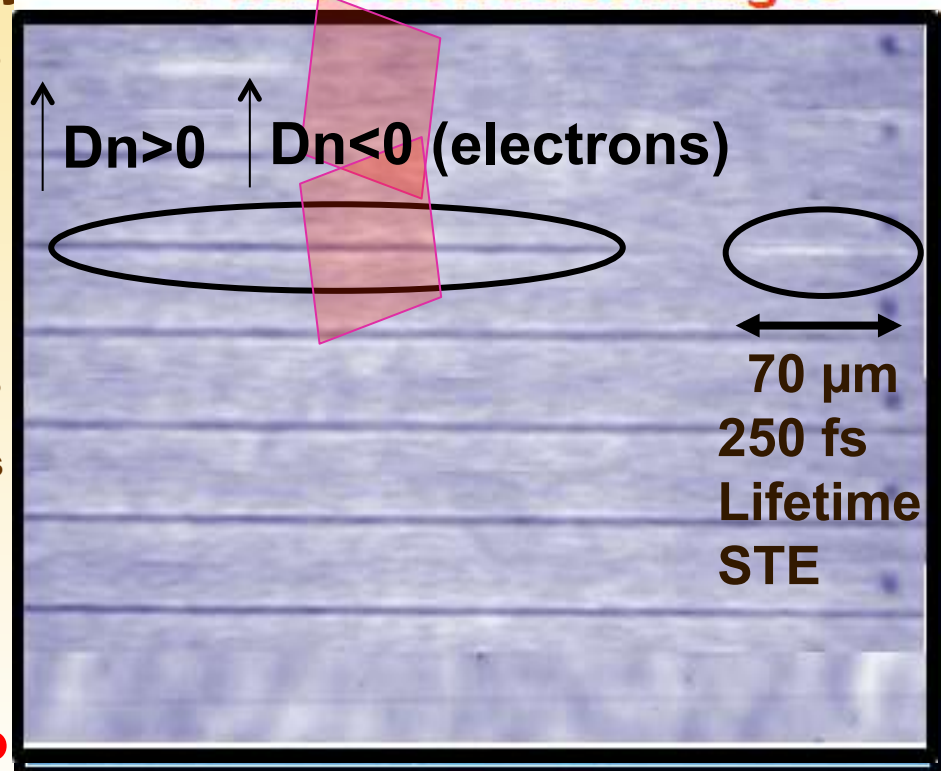
Optical transmission



Delay

Phase contrast images

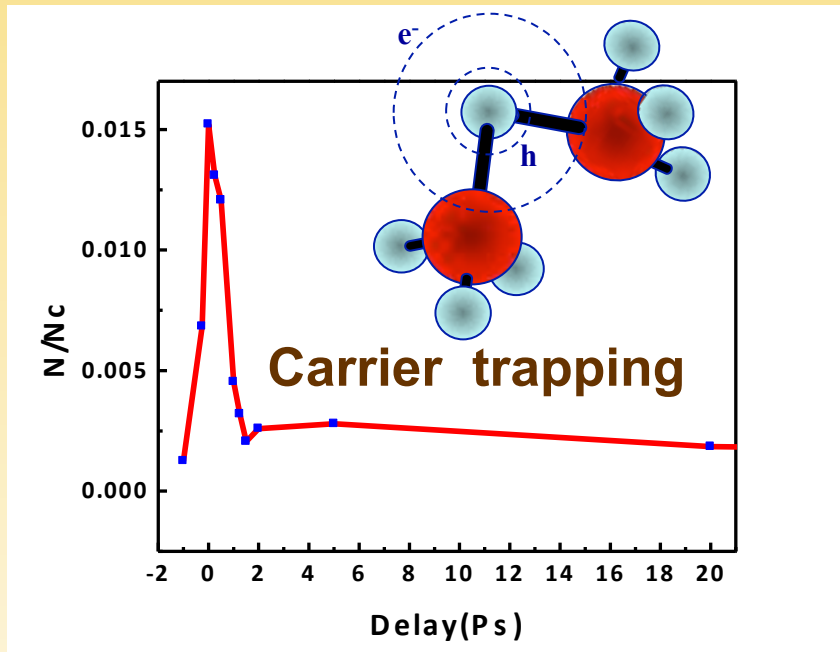
-0.4ps
0ps
0.3ps
0.6ps
0.9ps
1.2ps
5ps



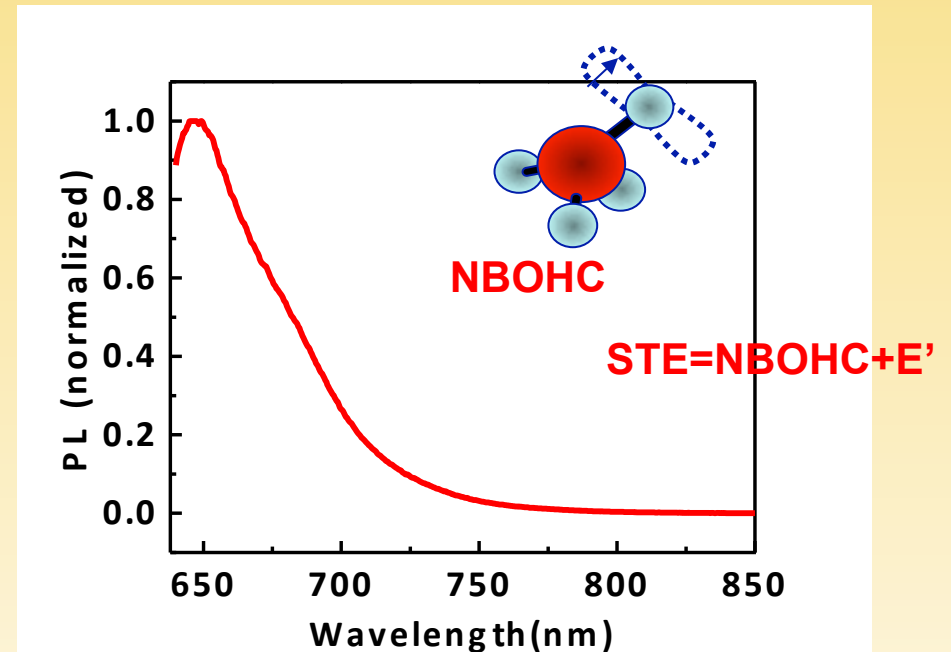
Fast decaying corresponds to

in brief: scenario for positive index (type I)

Time-resolved studies

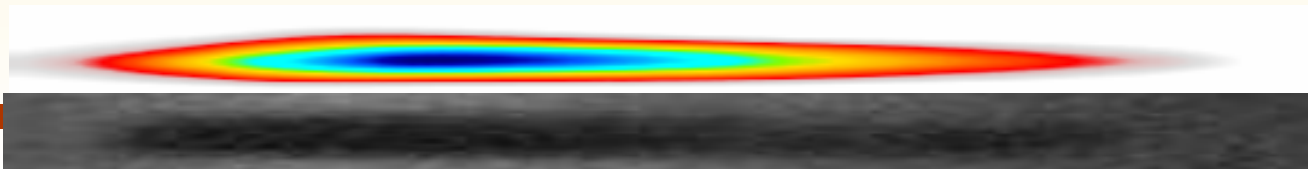


Photoluminescence studies



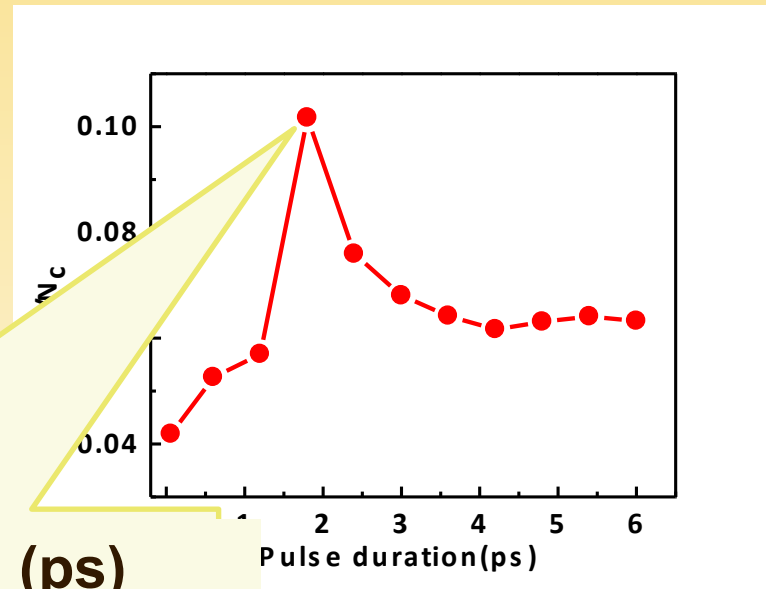
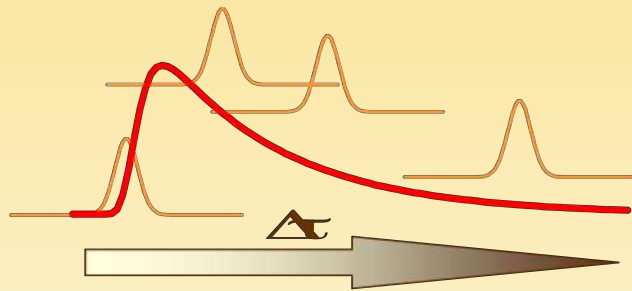
Carrier trapping \Rightarrow bond breaking \Rightarrow densification of Si-O rings

Defect assisted densification **leads to the formation of type-I structures**

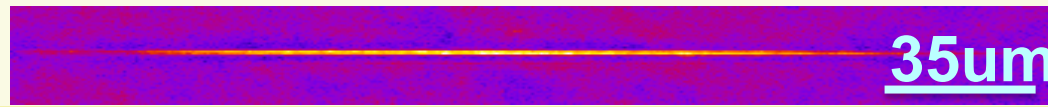


ultrafast dynamics: time-resolved imaging (ps)

Probing the material response:



Type-II uniform void structures (ps)



$\Delta n < 0$ $\Delta n > 0$



ultrafast dynamics: time-resolved imaging (ps)

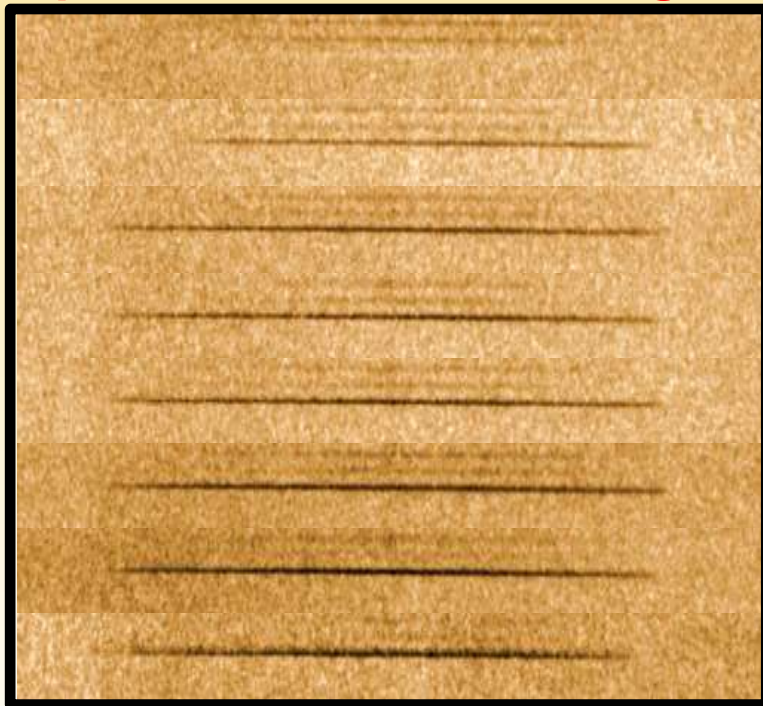
Far above the modification threshold (type II)

7 μ J
6 ps



Optical transmission

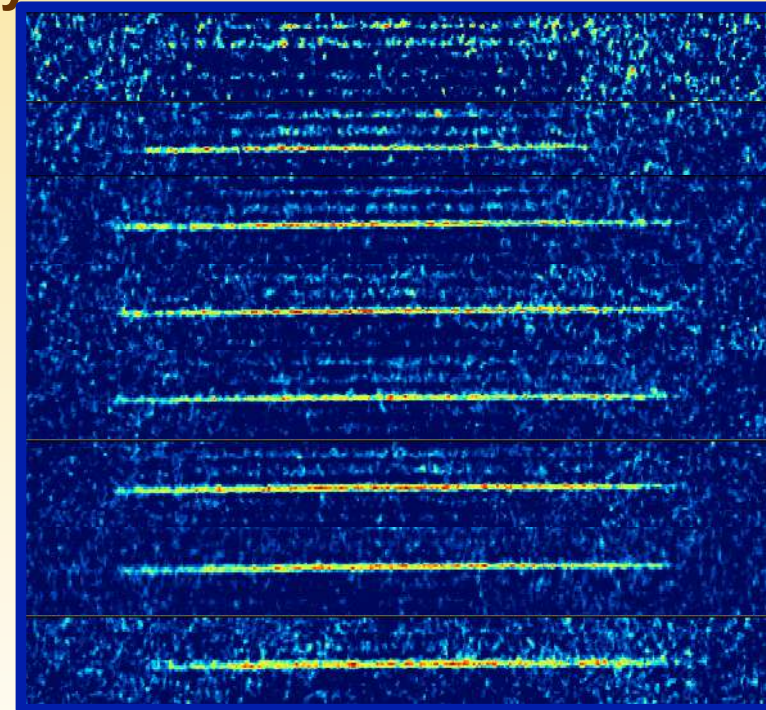
Optical transmission images



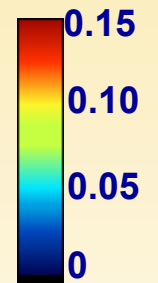
Delay

-3ps
0ps
3ps
6ps
9ps
50ps
1.5ns
6.25ns

Estimated Ne/Nc



Ne/Nc



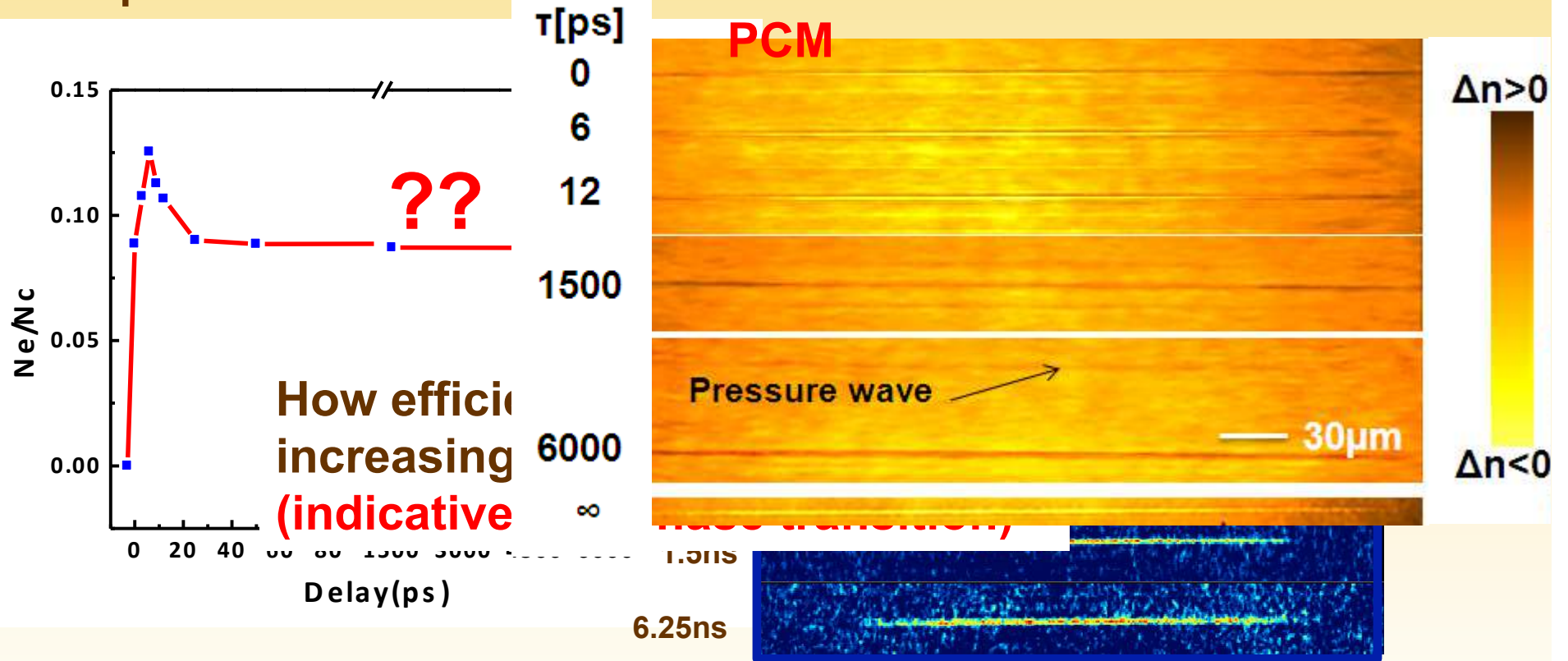
ultrafast dynamics: time-resolved imaging (ps)

Far above the modification threshold (type II)

7 μ J
6 ps



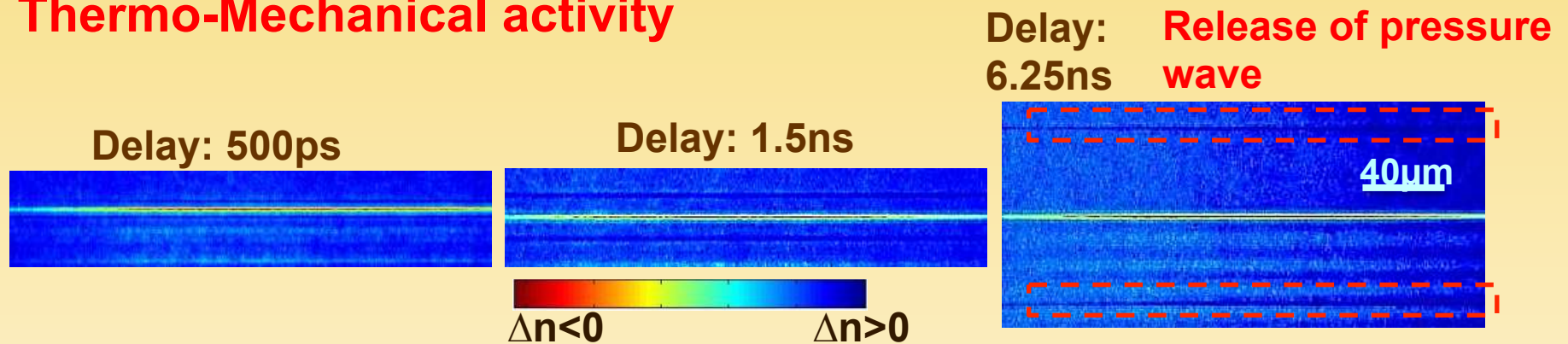
Optical transmission



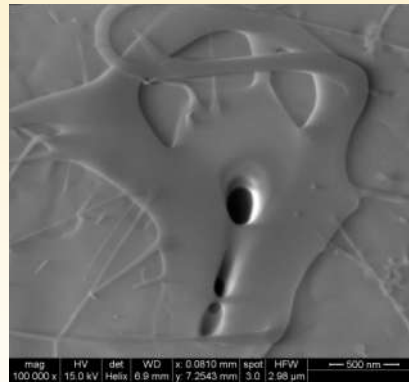
Residual absorption can be due to the existence of long-living electrons

in brief: scenario for voids

Thermo-Mechanical activity

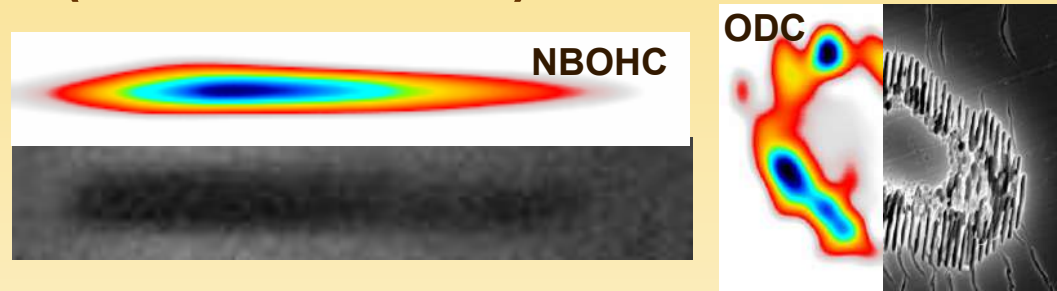


Hydrodynamic expansion and cavitation in the liquid phase lead to the formation of void (type-II) structures

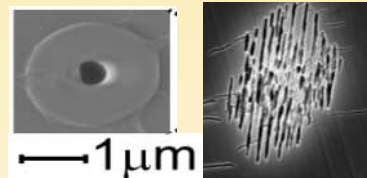


index control: mechanisms-dynamics/control-fabrication

- Structural transitions ($\Delta n > 0$ or $\Delta n < 0$) are controllable via electronic density

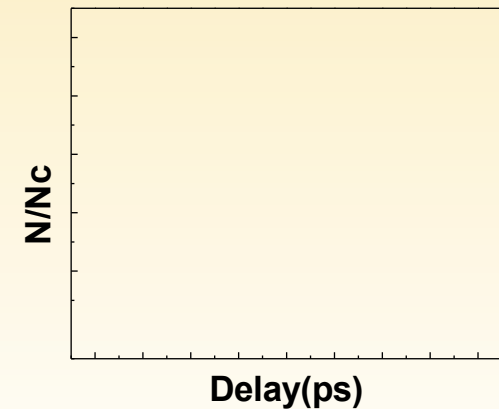


- Nanoscale is achievable



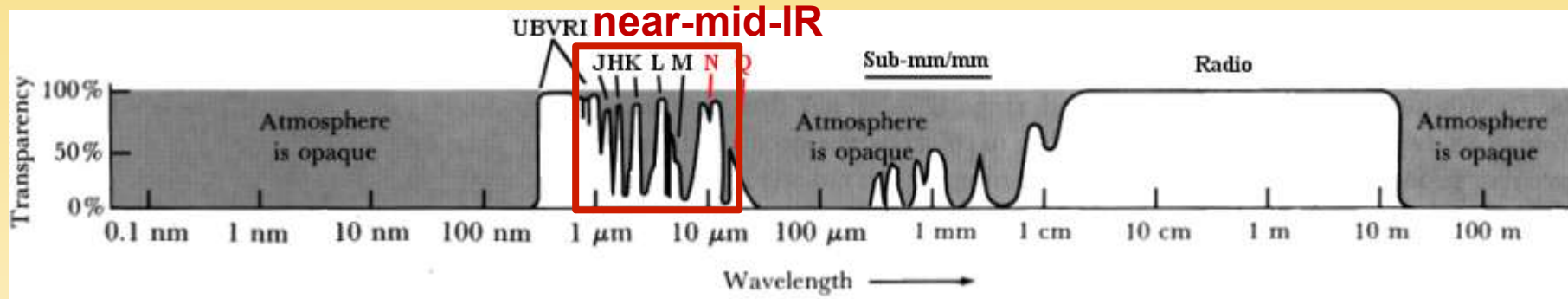
- Transient dynamics

- Pulse duration/form is a key parameter



Applications to photonics

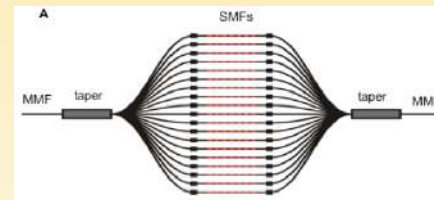
guided optics in the mid-IR (MIR photonics)



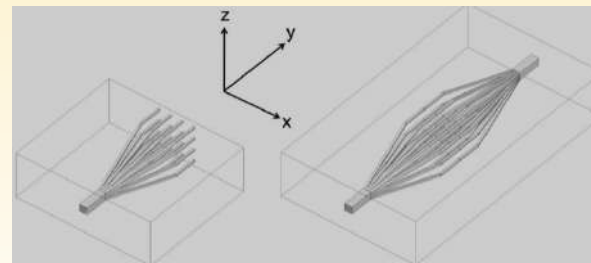
Mid-IR-Astronomy



Design requirements



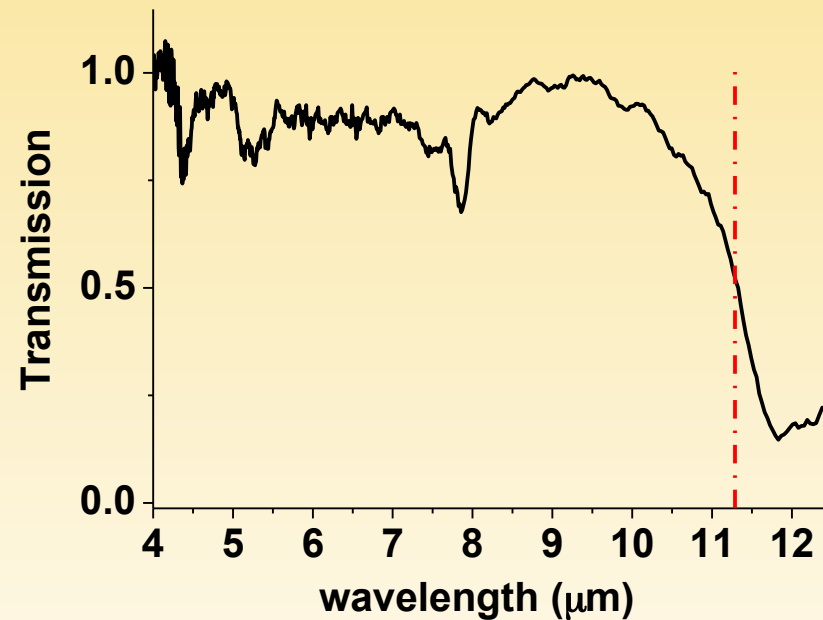
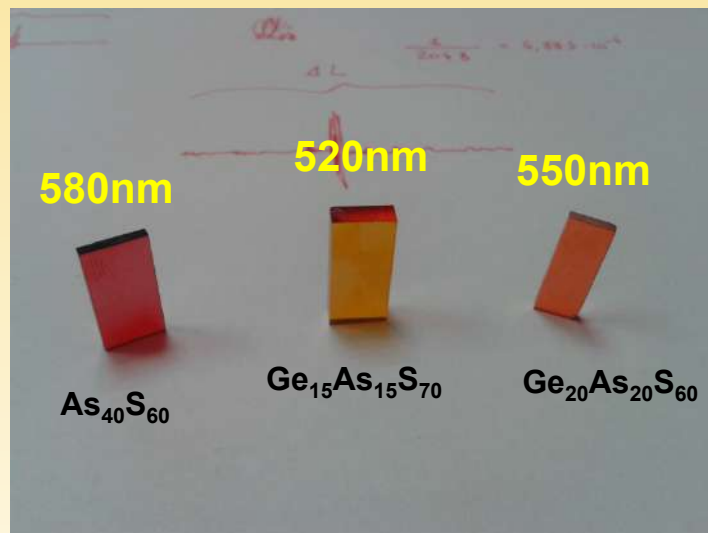
2D
↓
3D



Material requirements

chalcogenide glasses for the mid-IR

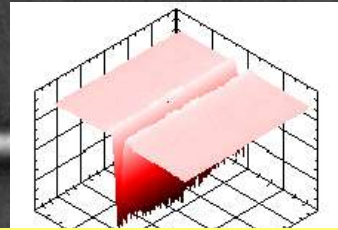
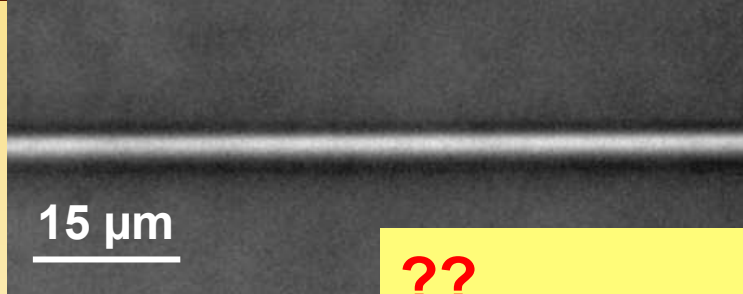
Interesting class of materials :
As-S; Ge-As-S systems



- Band-gap (two-photon absorption)
1.2 cm/GW@800
- High n_2 (1000 \times n_2 -SiO₂)

photoinscription in S-based glasses

As_2S_3



$\Delta n < 0$ TYPE II

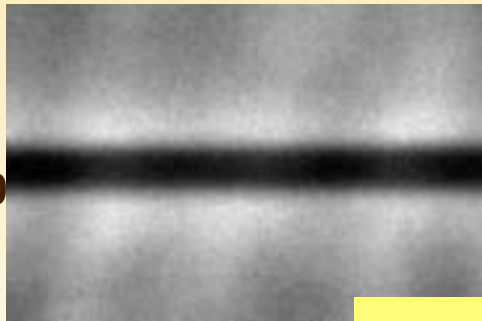
Thermomechanical

??

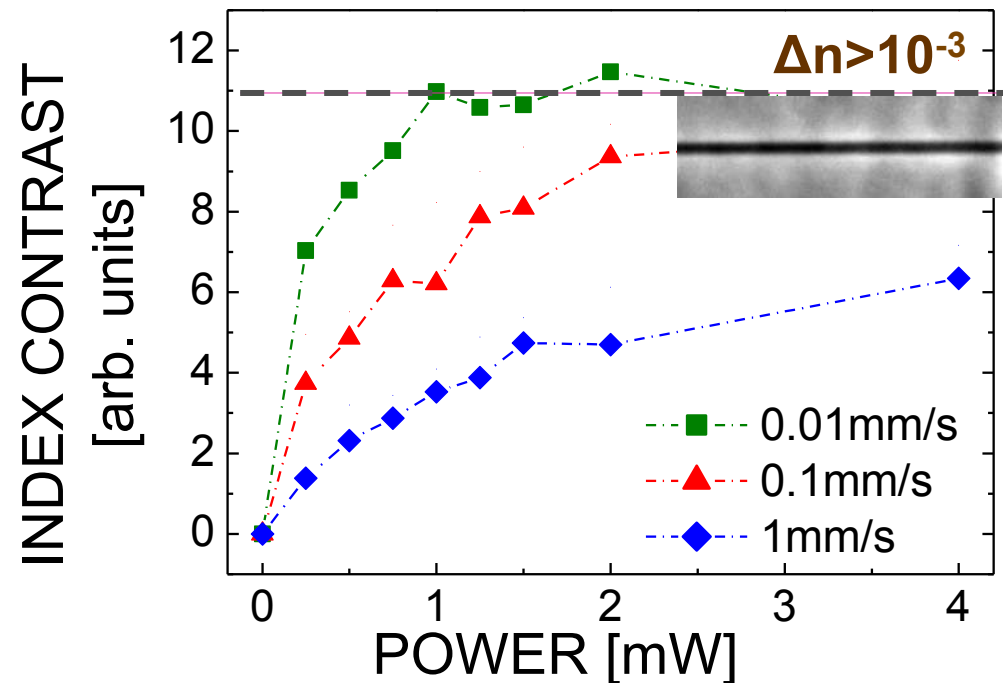
Quasi no guiding!

Solut

$\text{Ge}_{15}\text{As}_{15}\text{S}_{70}$



What
Role
(cov

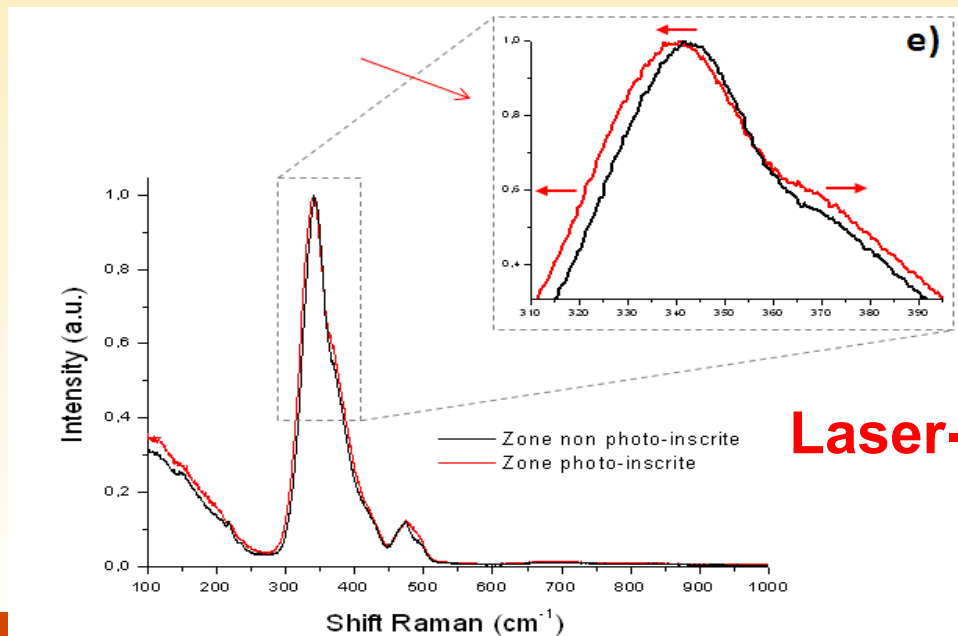


photoinscription in S-based glasses: T history

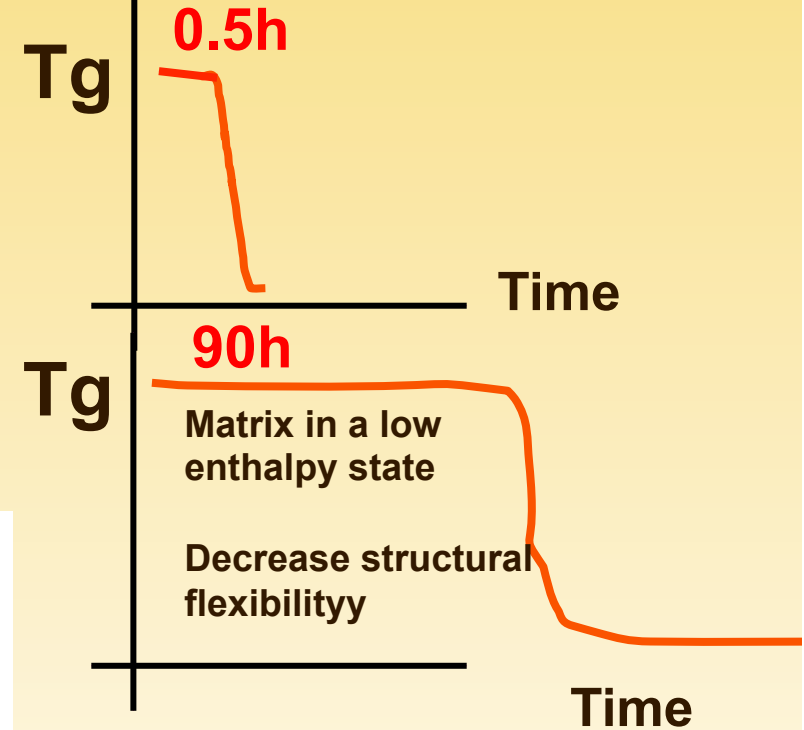
SHORT ANNEALING



LONG ANNEALING

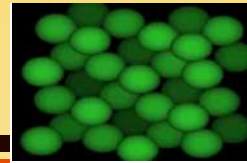


Laser-induced structural disorder



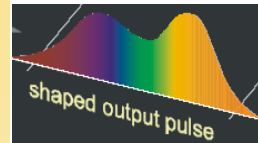
optical design

Material response:
-structural
(role of metastability)



Material design:

Matrix connectivity (Ge)



Pulse design:

Optimally adapted

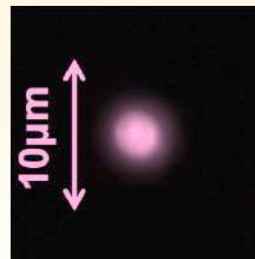
Design of waveguides: **normalized frequency (SM)**

V-number
(800nm)

0.2



1.8



V-number
(3.39µm)

0.3 (d=8µm)

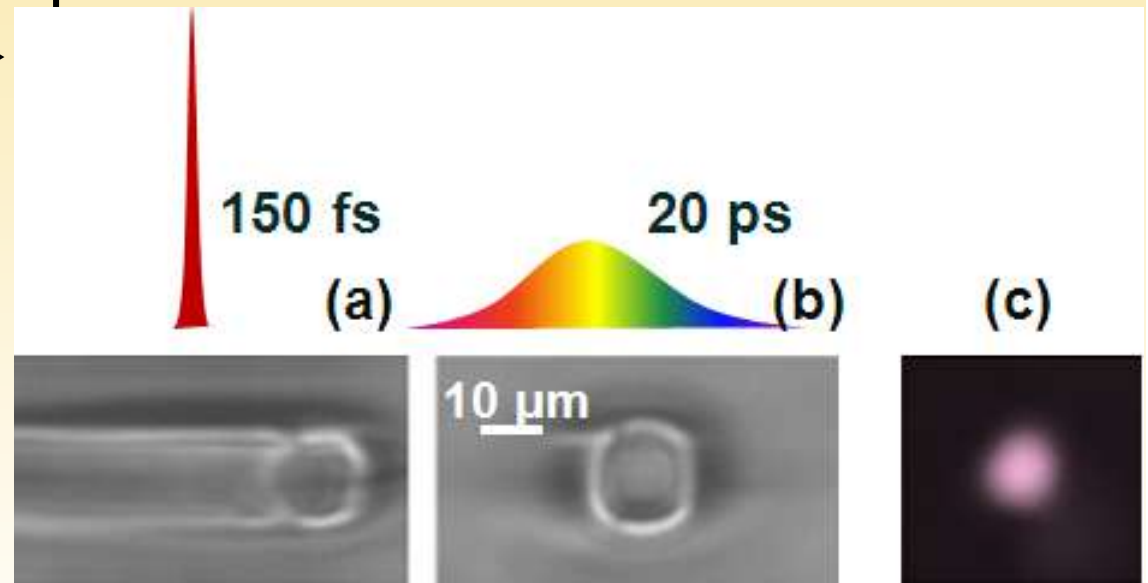
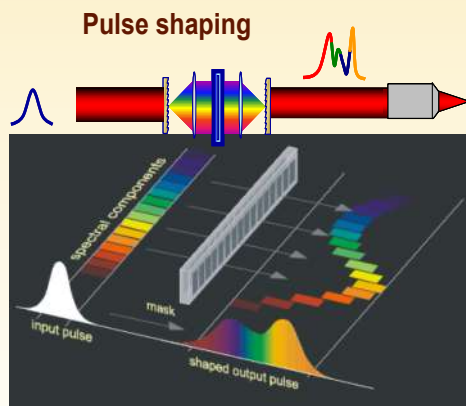
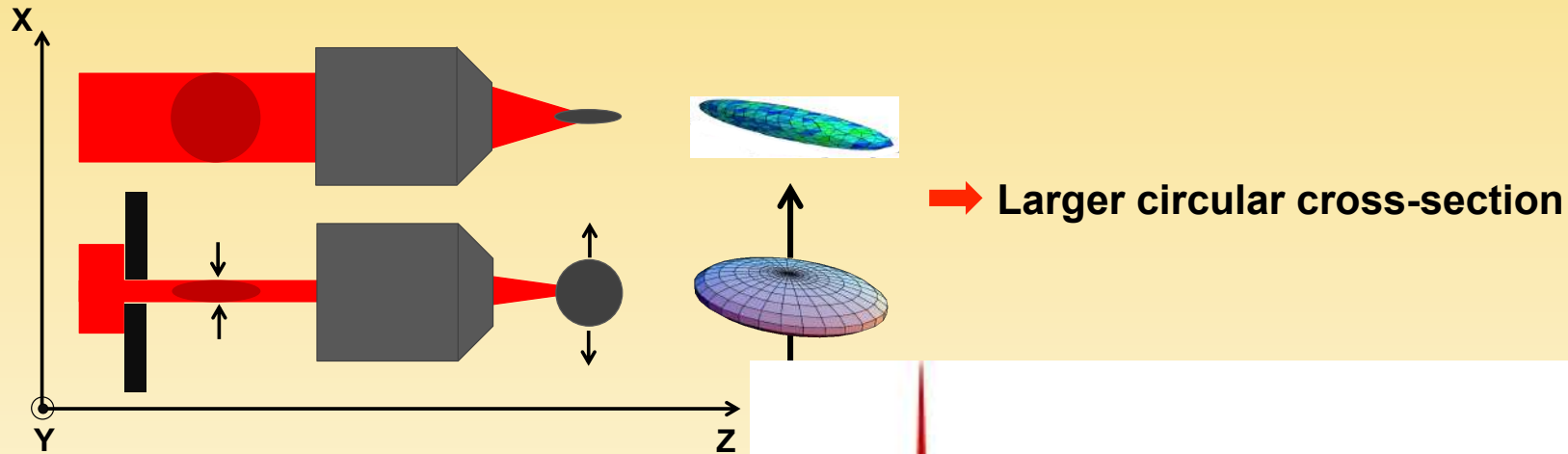


1.8 (d=35µm)

**we need to
upscale the
waveguide
cross-section**

upscaling the mode-section

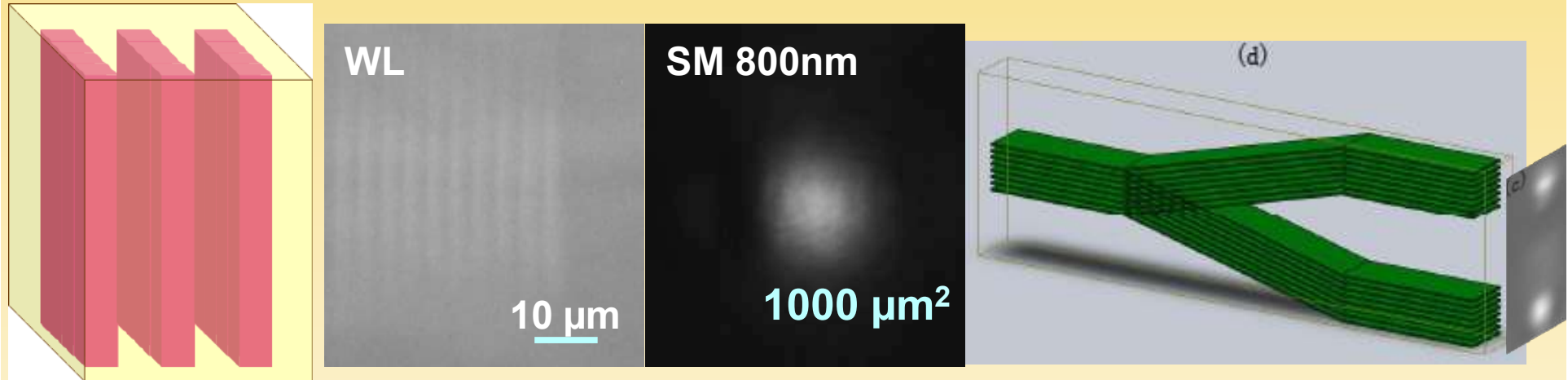
Slit-Shaping (Transversal) Cheng&Sugioka OL 2003



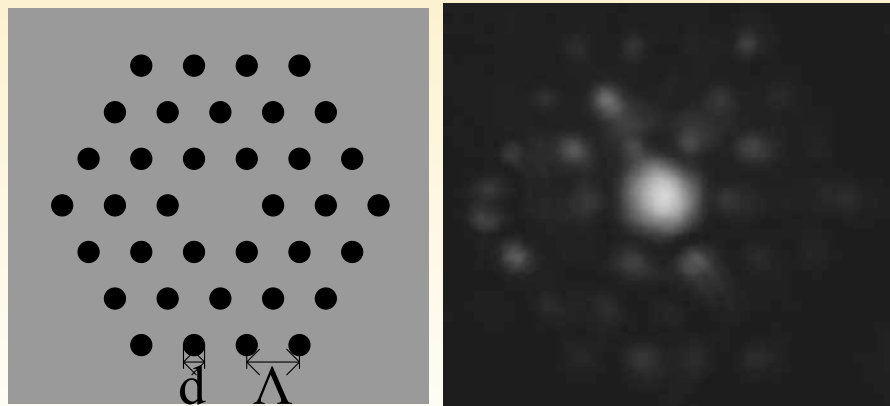
NLO distortion

upscaling the mode-section (LMA concepts)

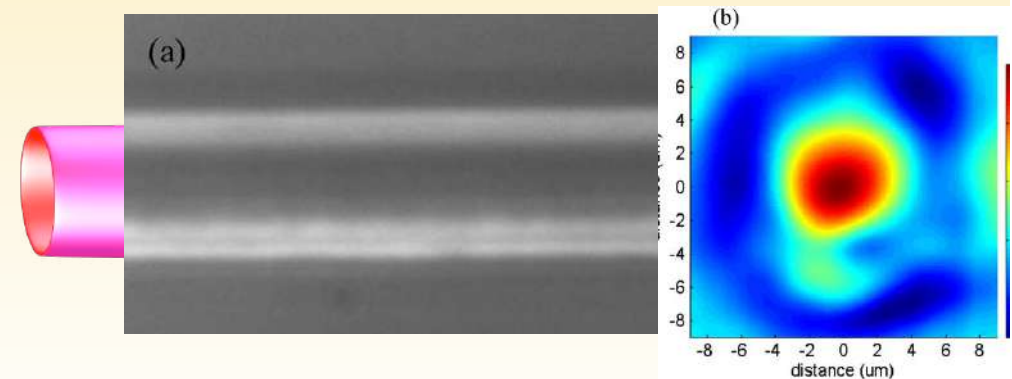
Extended core waveguide



PCF core waveguide

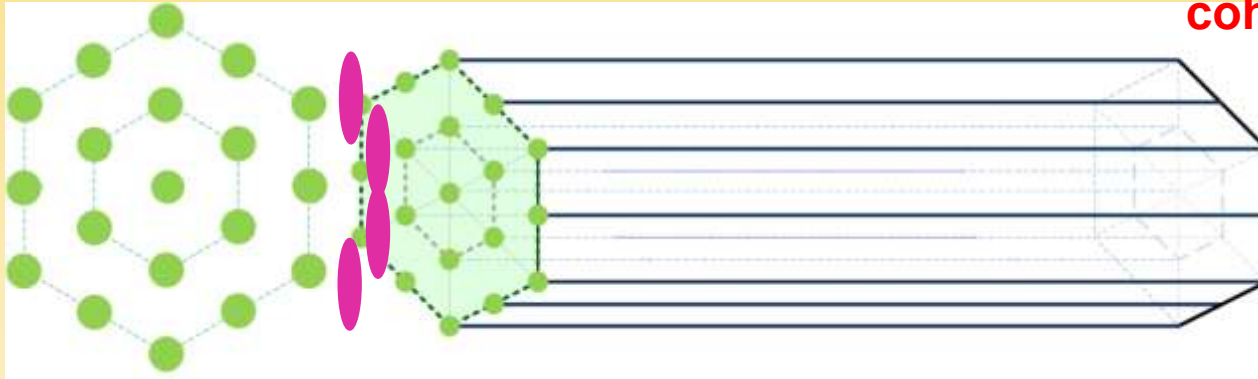


Vortex HO Bessel waveguide

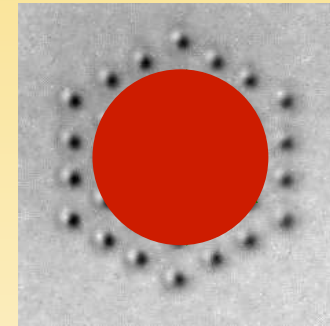


upscaling the mode section

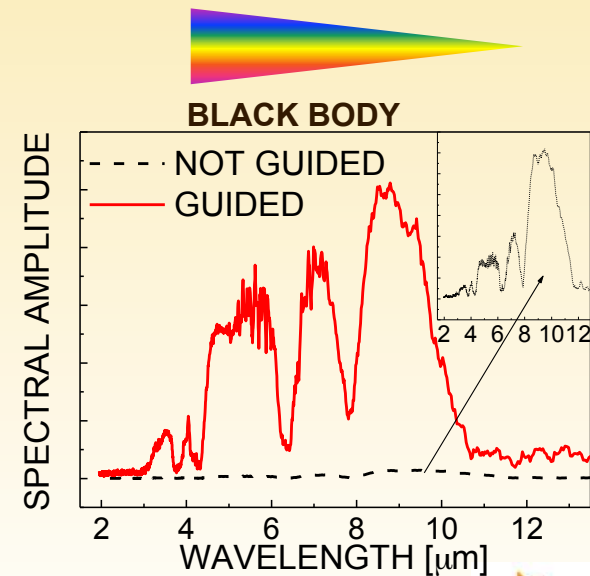
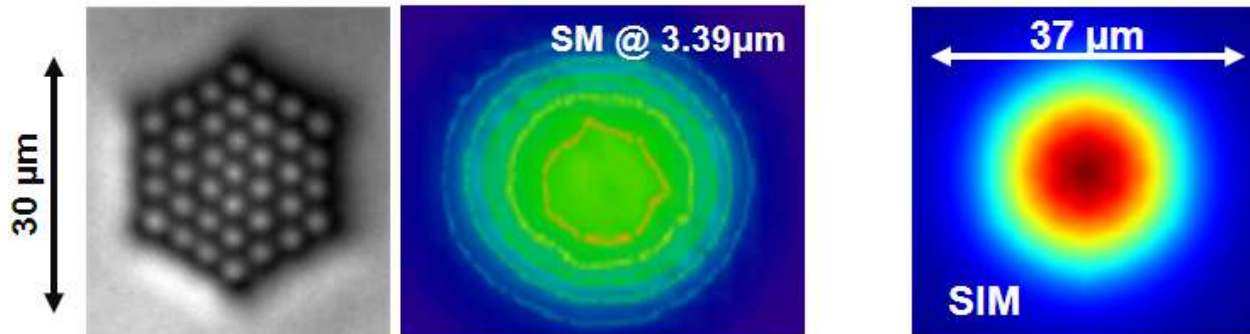
Multicore & evanescent coupling



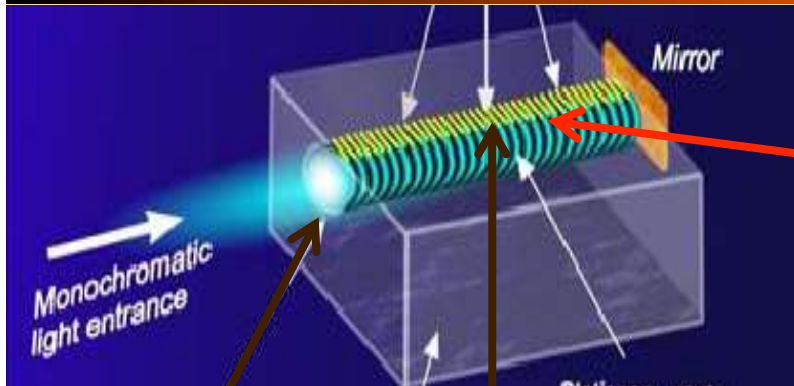
Multicore waveguide: coherent mode superposition



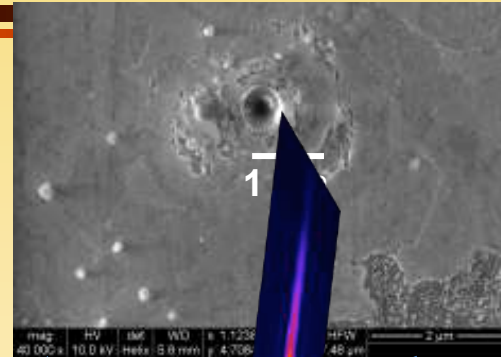
MIR test of multicore waveguides



embedded spectrometers



Interference
=FT=spectrum

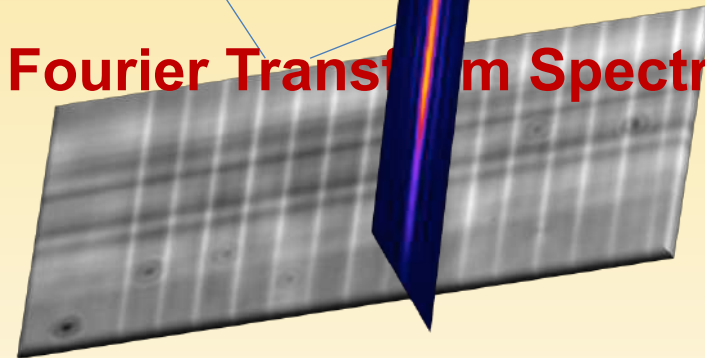


SWIFTS: Stationary wave integrated Fourier Transform Spectrometer

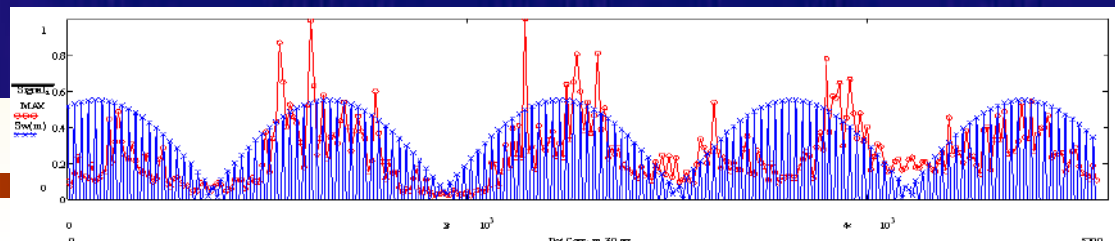
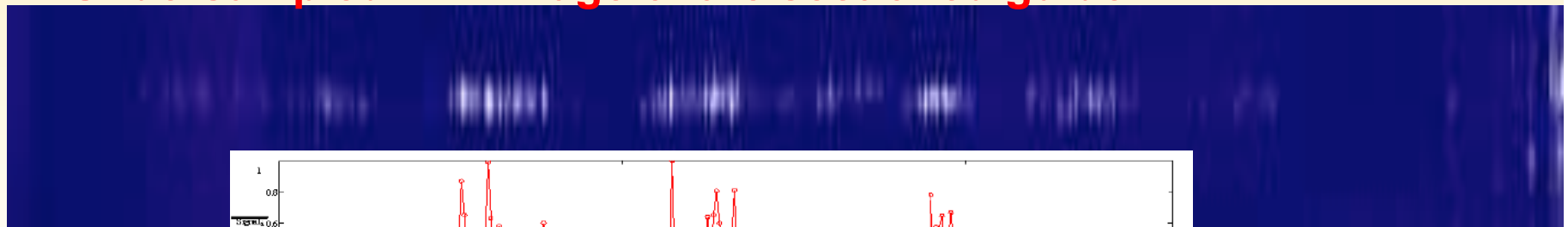
E Coarer Nat. Phot 2007

waveguide

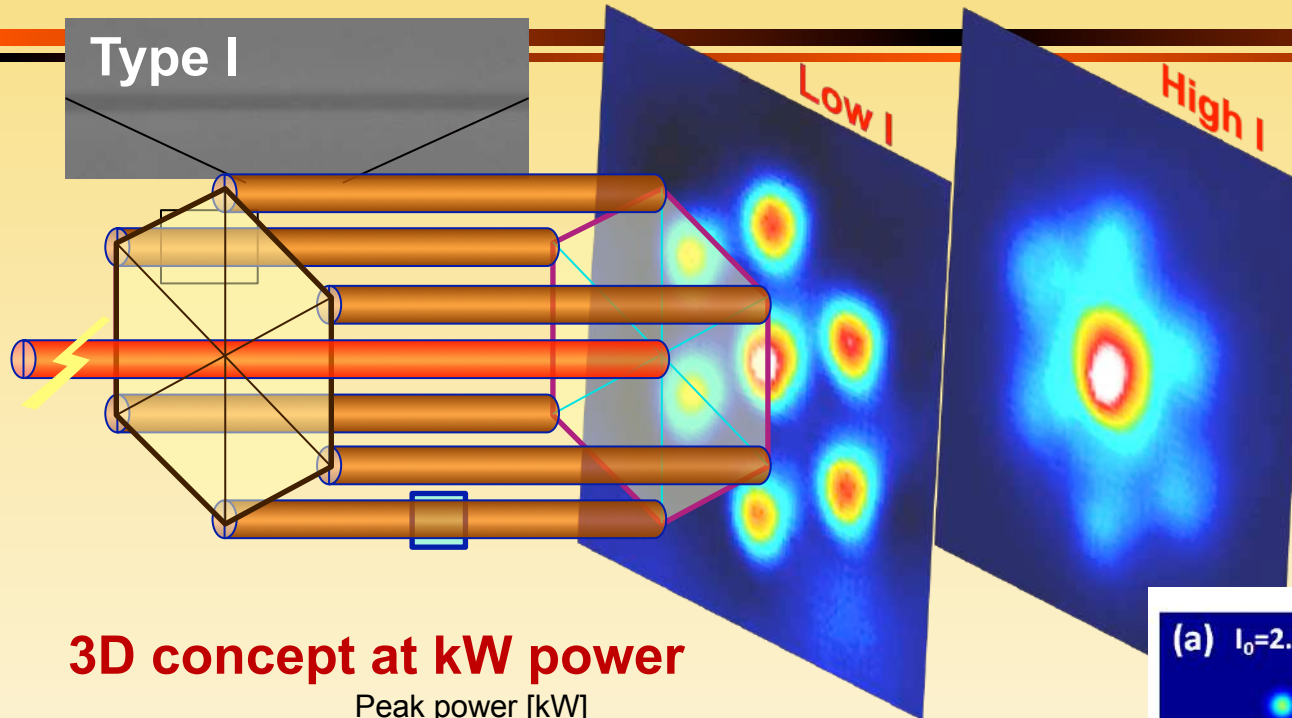
Nonperturbative access to
evanescent field



Undersampled MIR Image of the sectioned guide



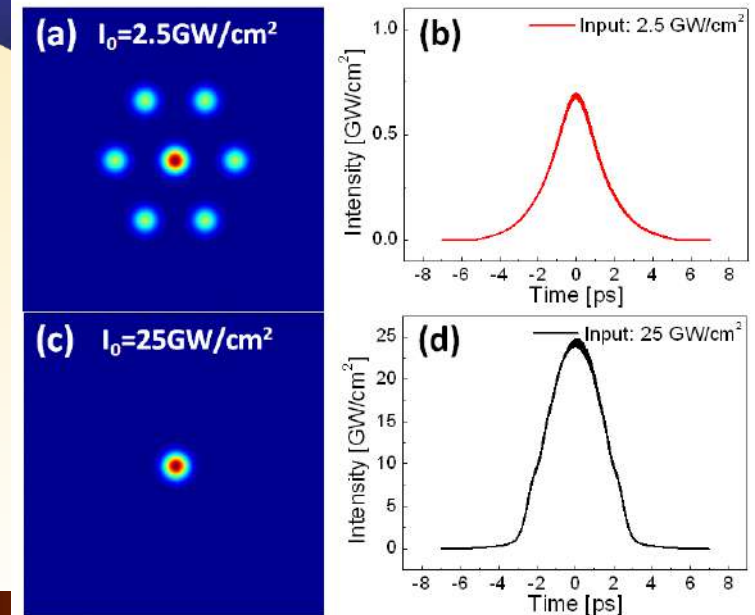
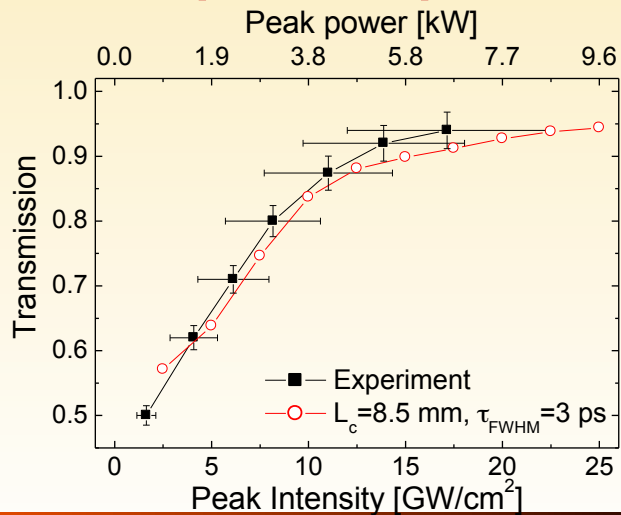
nonlinear functions



Saturable absorber
 $n = n_0 + n_2 I$ (Kerr)

Discrete NLO Schrödinger

3D concept at kW power

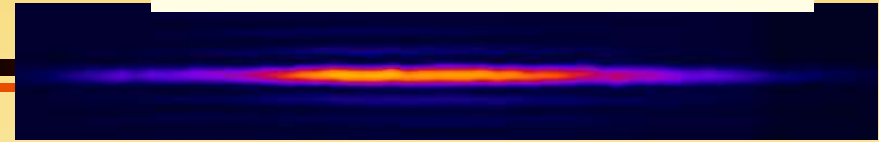


conclusions

- **Controllability / Optimality in laser-matter interaction**
design of structural modifications
- **Dispersion design: breaking the diffraction limit**
- **3D Photonics:**
Linear and nonlinear LMA guiding functions

conclusions

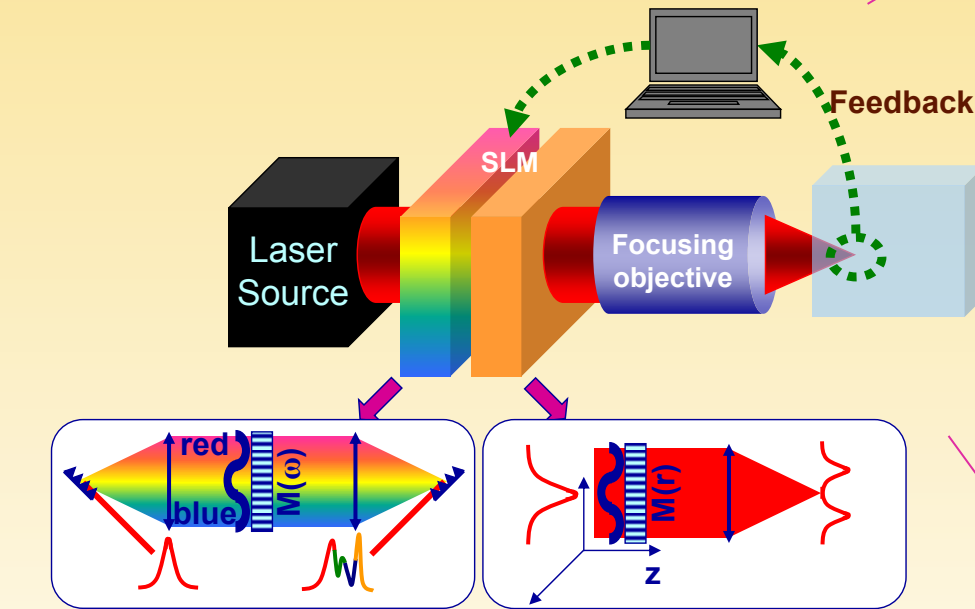
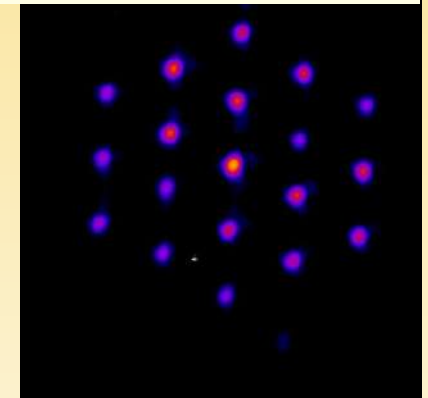
Non-diffractive beams



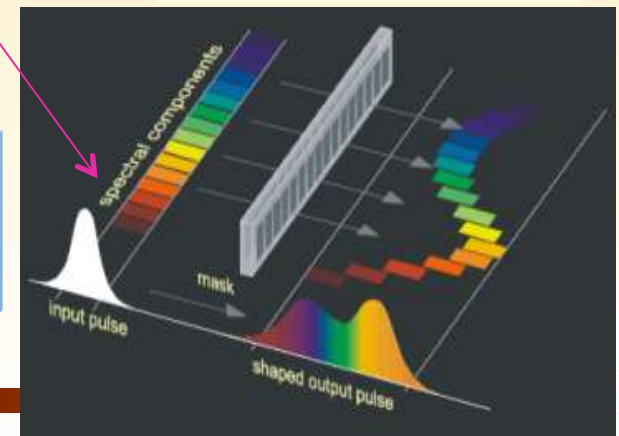
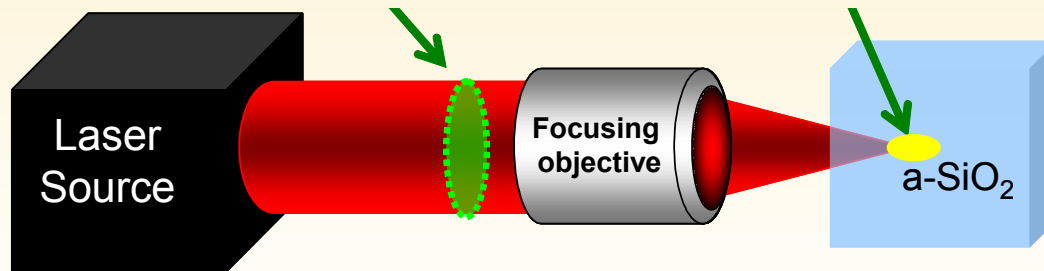
High flexibility!

Designing light-matter interaction

Parallel processing



Time-shaping



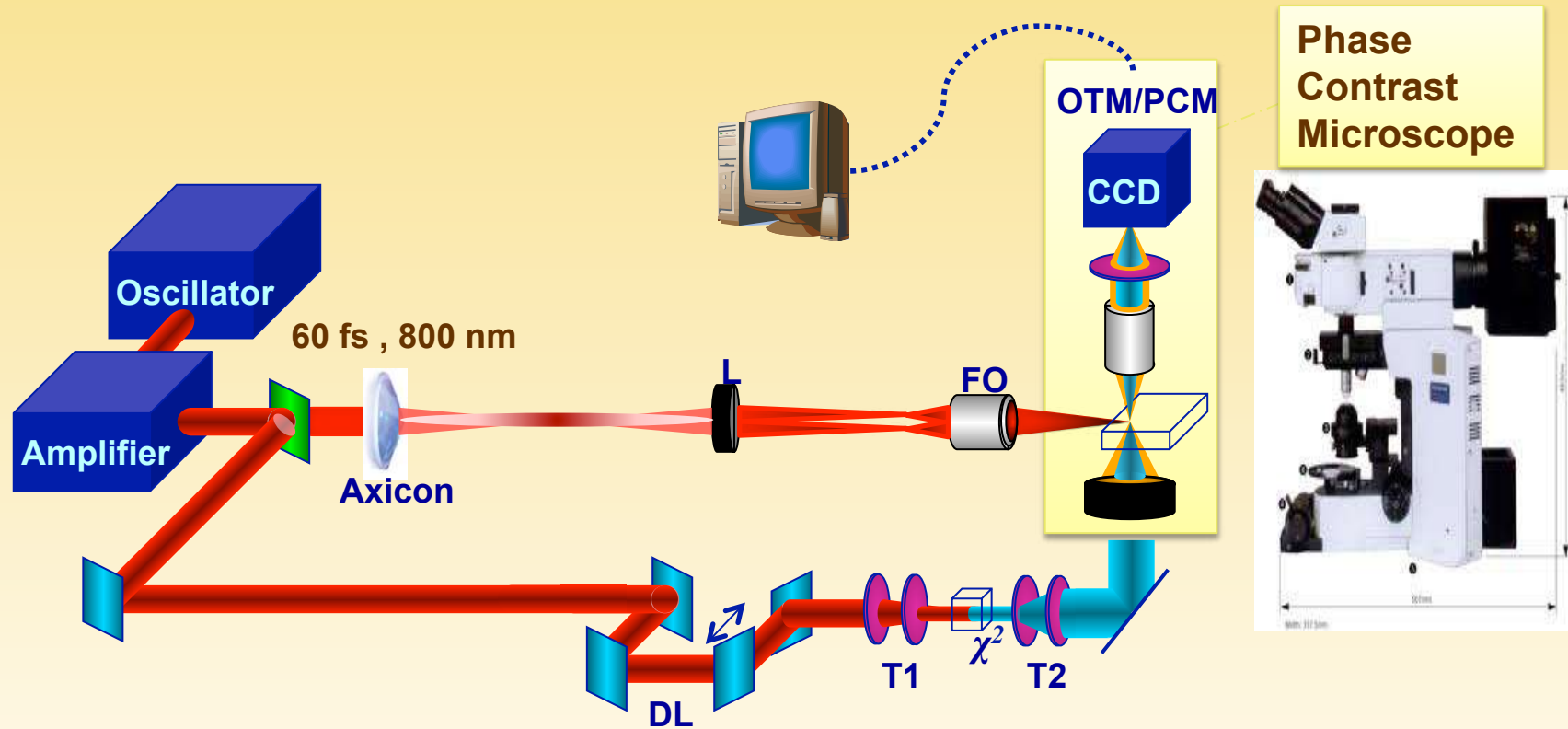
thanks to:



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C. Mauclair A. Mermillod M. Zamfirescu G. Cheng
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M. Bhuyan S. Minardi J. Troles G. Martin
L. Calvez V. Nazabal E. LeCoarer
P. Kern

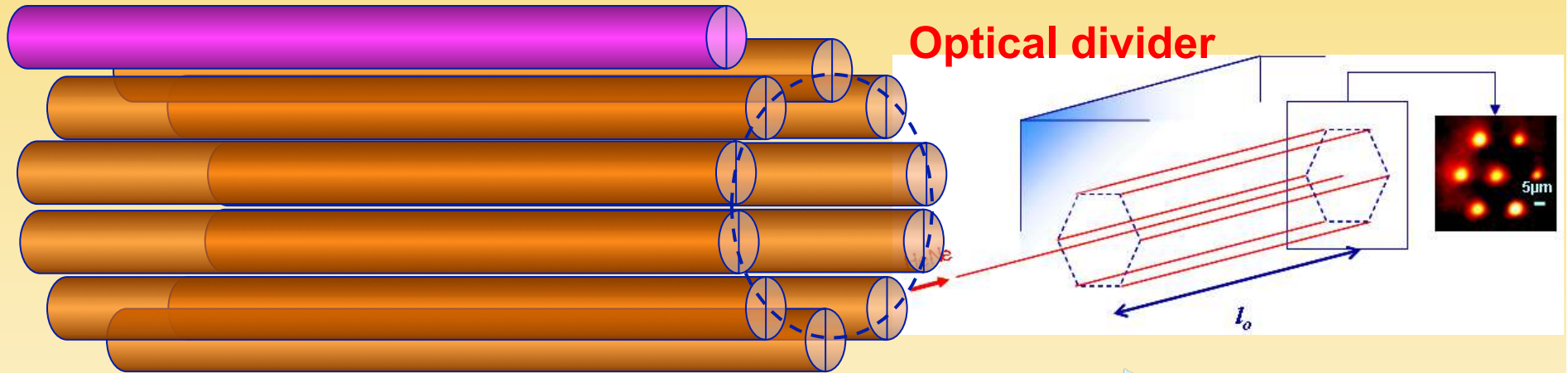


Ultrafast dynamics: time-resolved imaging

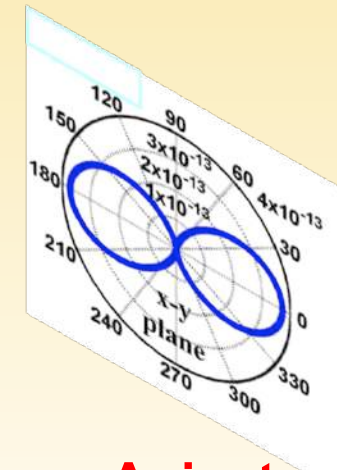
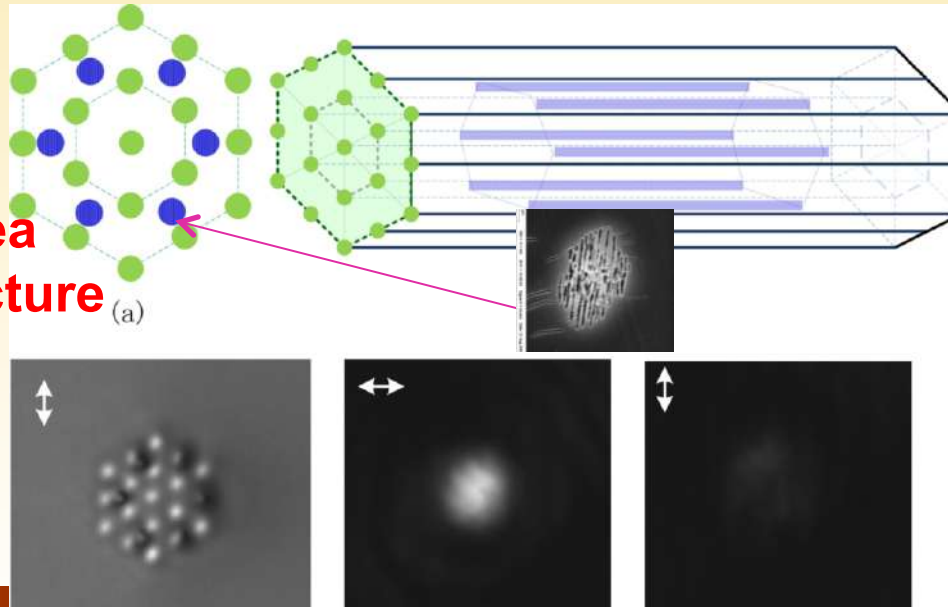


Time resolved microscopy setup; **sub picosecond temporal resolution**

3D periodic structure: evanescently coupled



LMA
large-mode-area
Multicore structure

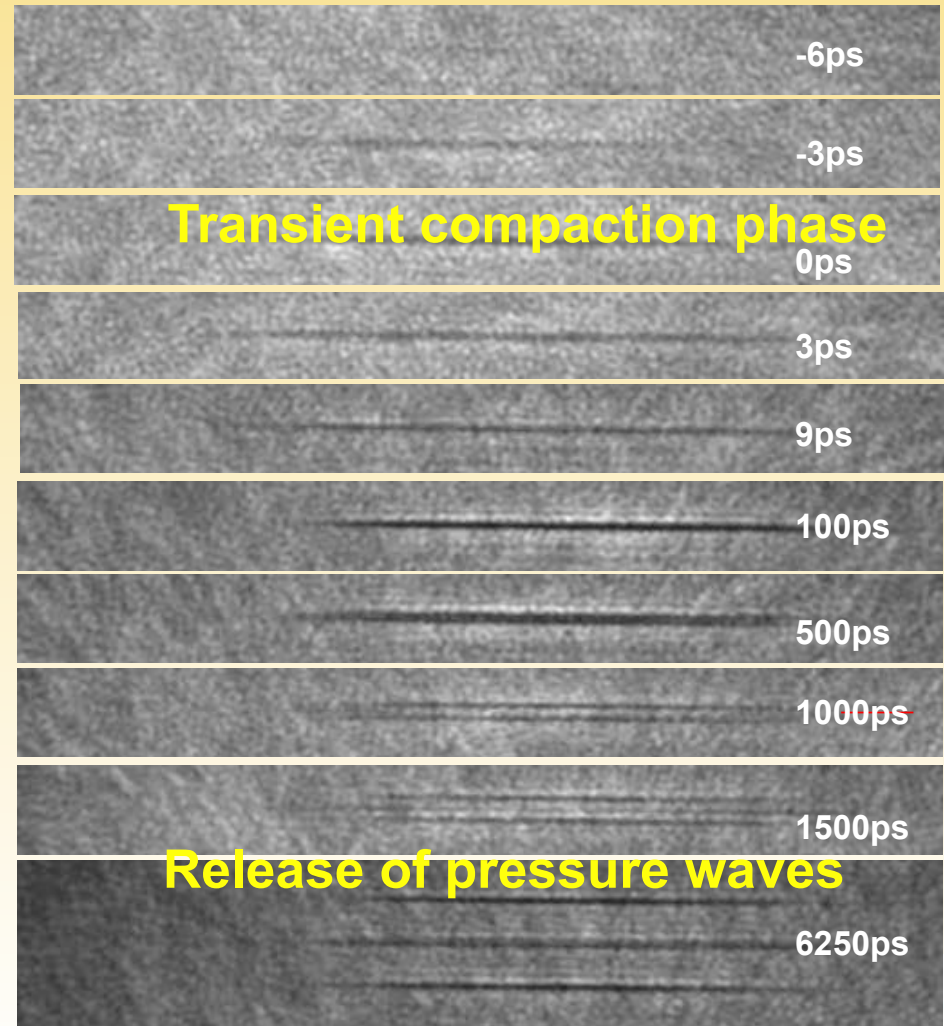
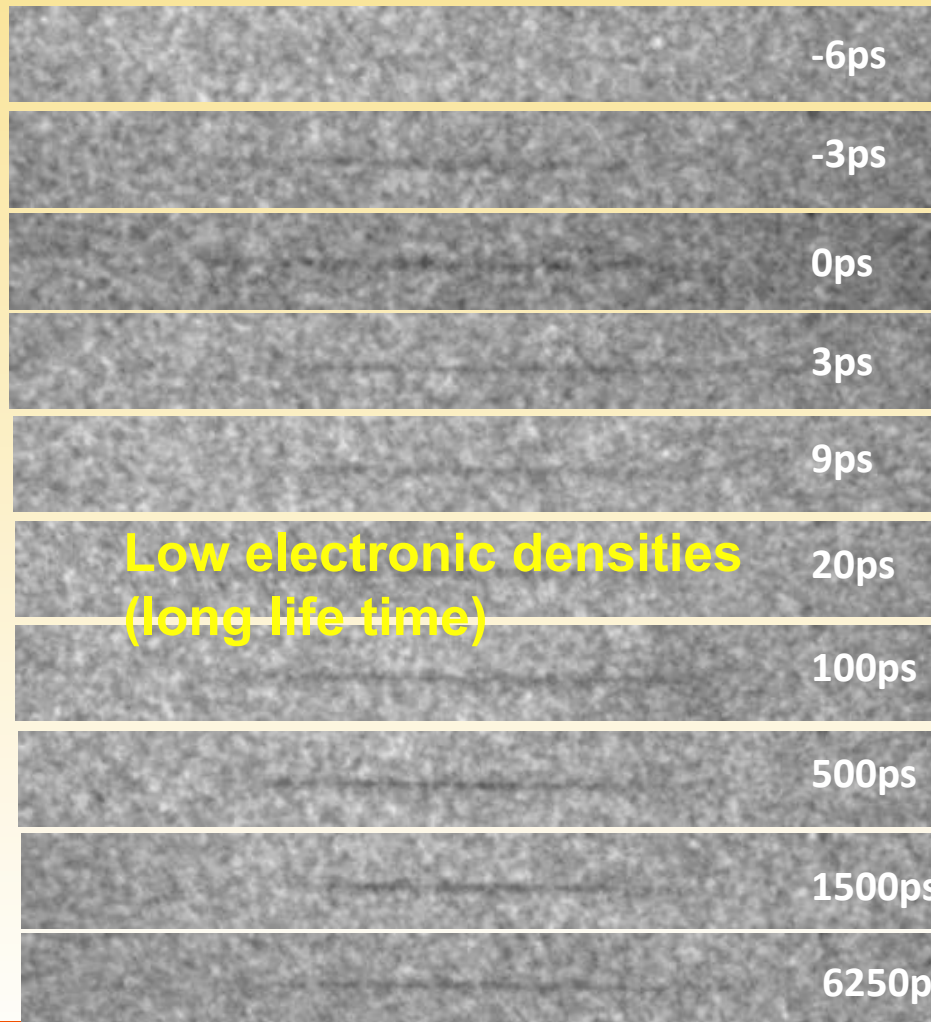


Anisotropic light transport

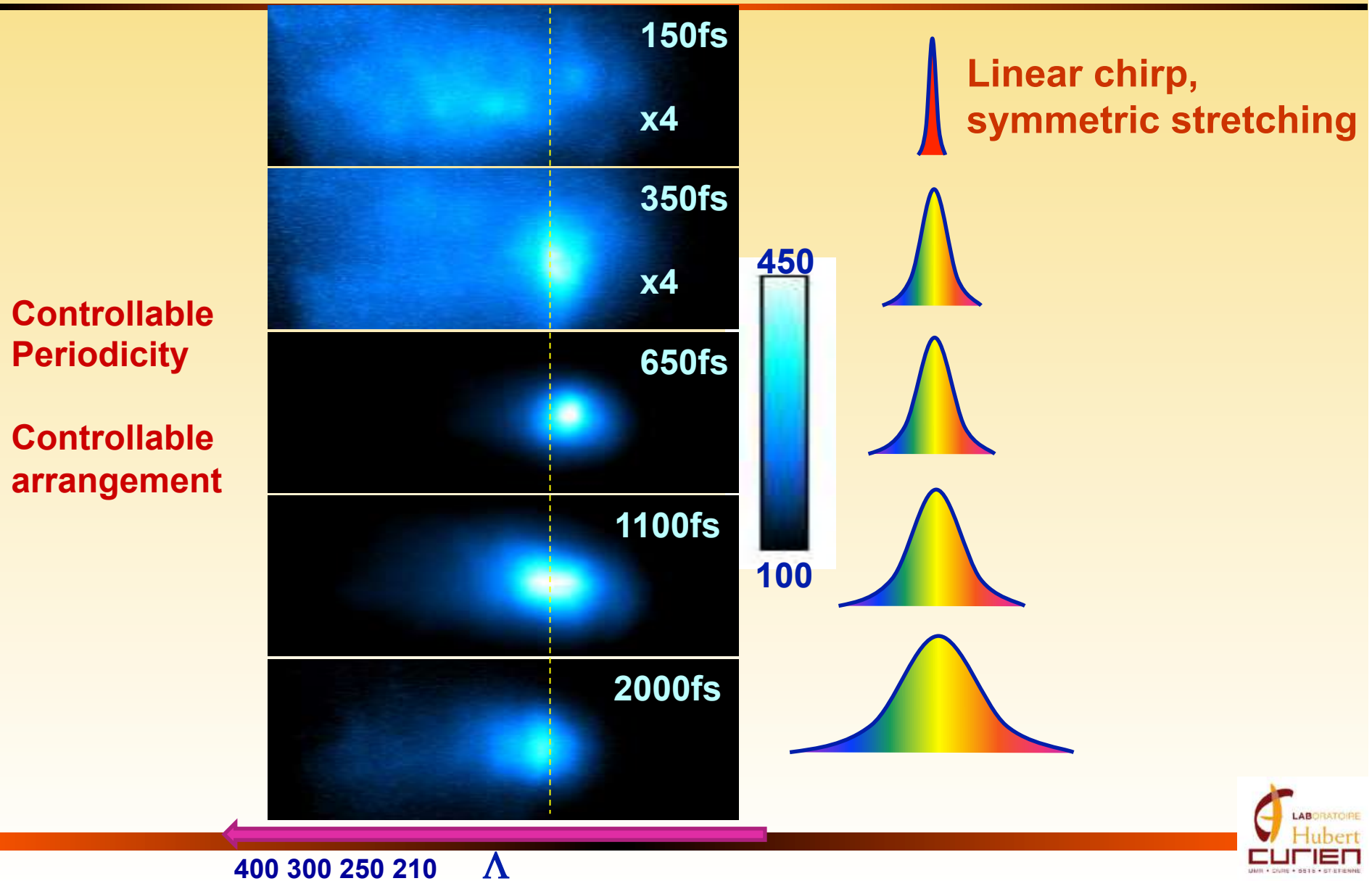
Dynamics of structural transformations

Transmission

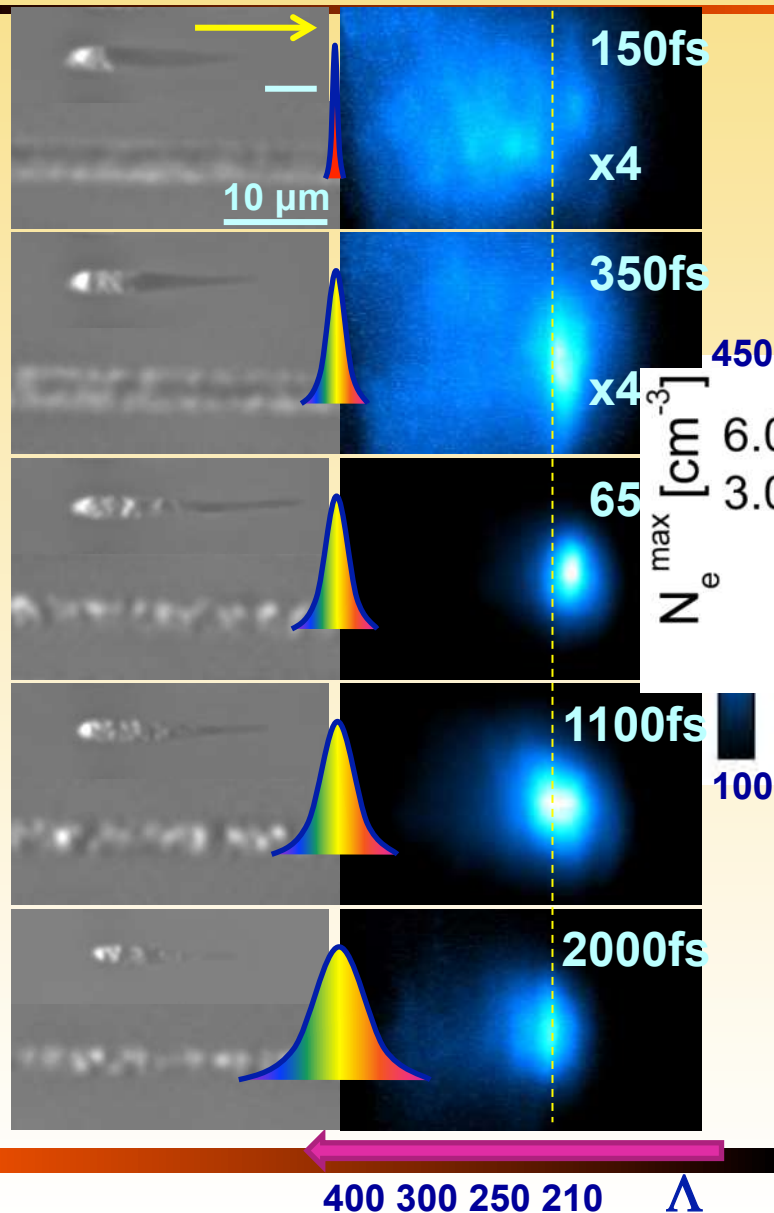
Phase



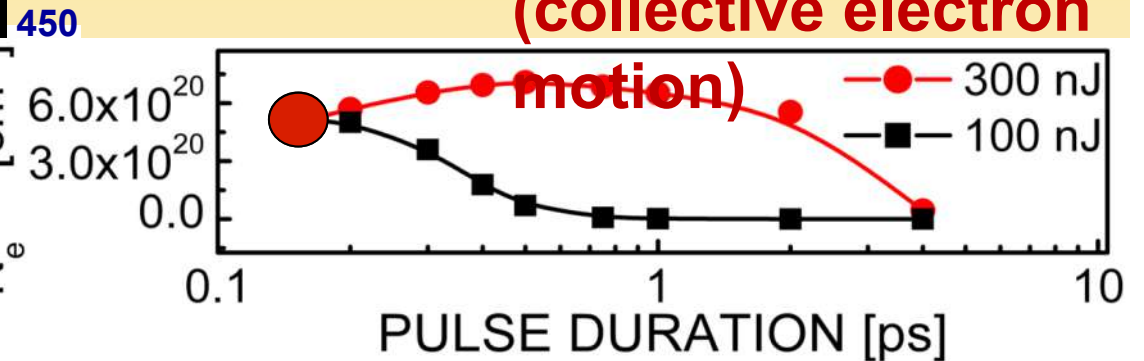
nano-control via diffraction feedback: a-SiO₂



nano-control via diffraction feedback: a-SiO₂

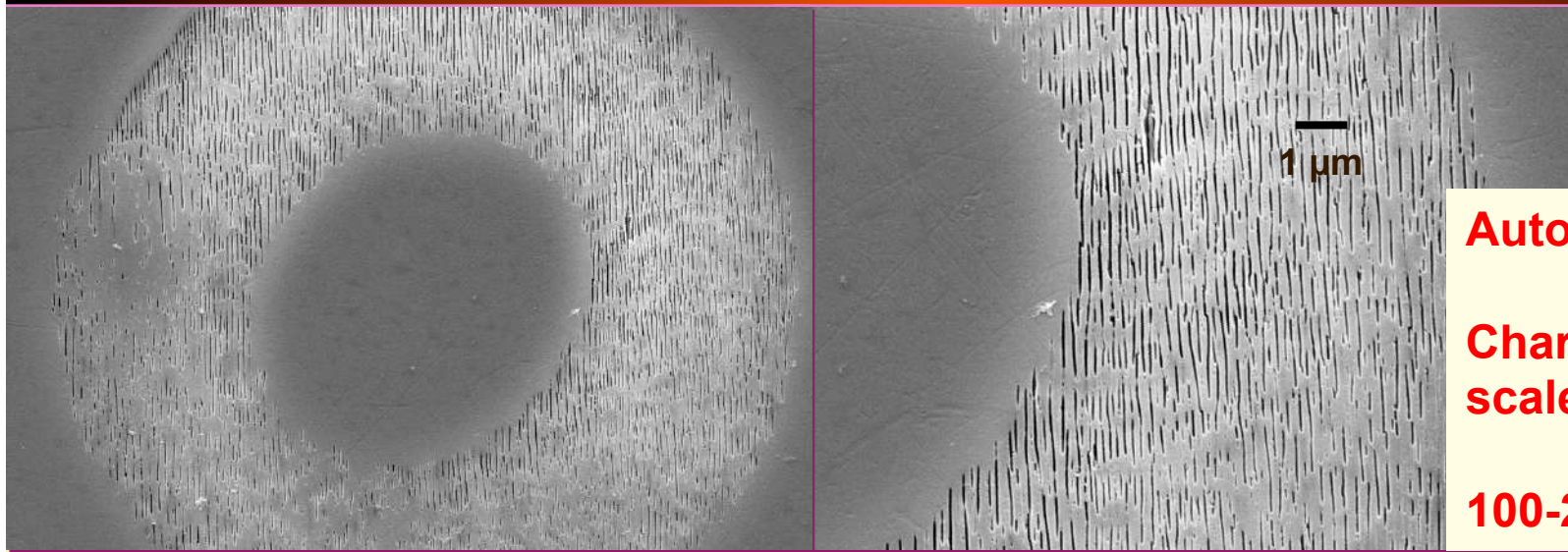


Electron density control enabled (collective electron motion)



Non monotoneous N_e -max 0.6ps

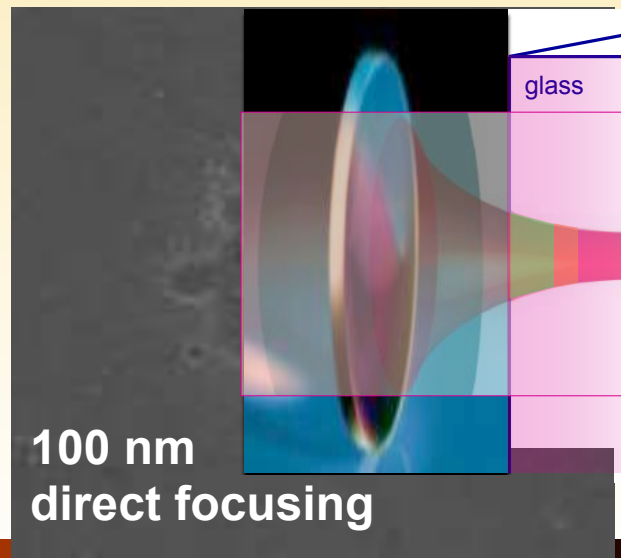
laser nanostructuring: beating the diffraction limit



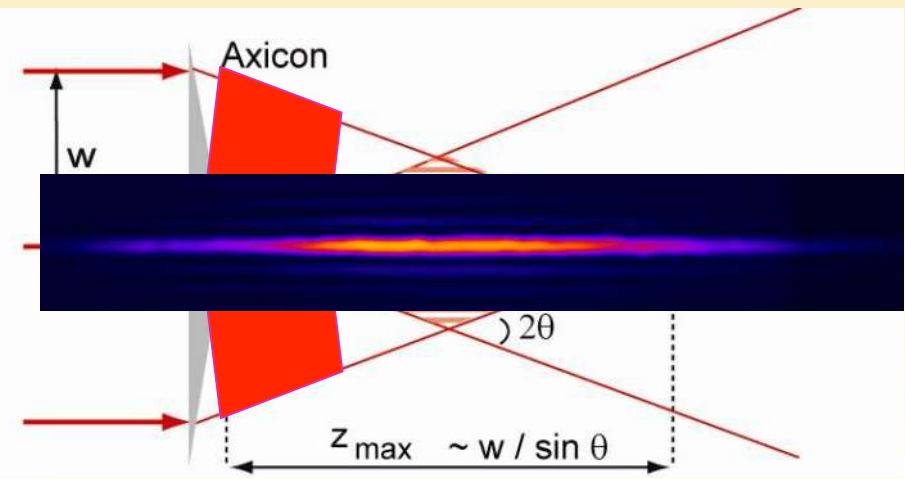
Auto-organization

Characteristic scale

100-200nm



**100 nm
direct focusing**



optical functions: a-SiO₂

- Polarization maintaining waveguides
low-loss + anisotropy

